

## The RD50 testbeam and the related simulations studies

M. Bomben<sup>1</sup> & I. Rubinskyi<sup>2</sup>

<sup>1</sup>LPNHE, Paris <sup>2</sup>DESY



# Outline

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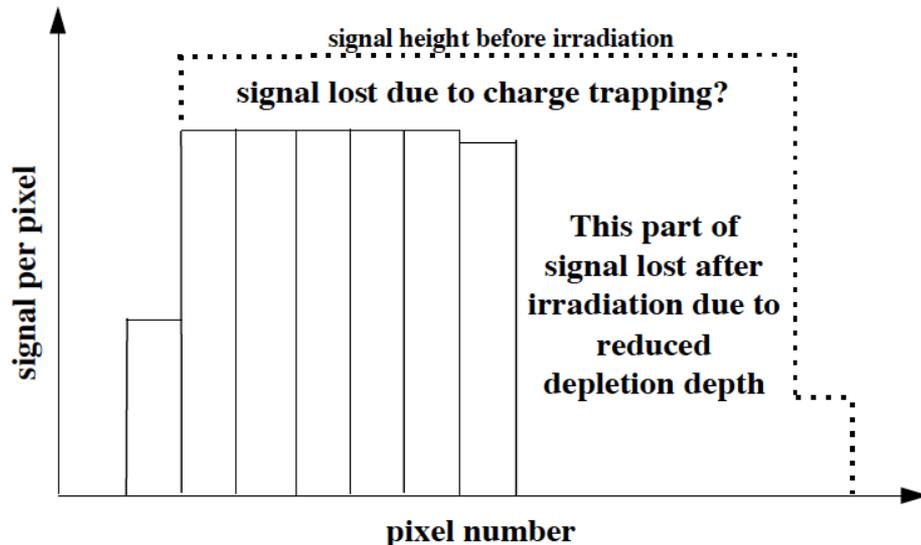
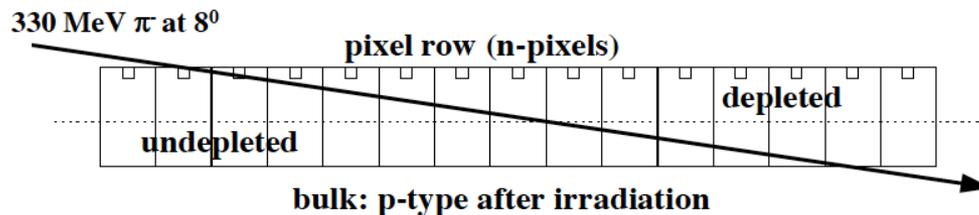
- The project
- The testbeam
- The simulation studies
- Conclusions & Outlook



# THE PROJECT

# Grazing angle technique

- Technique developed by Henrich, Bertl, Gabathuler & Horisberger ([CMS note 1997/021](#))



- Tracks enter at shallow angle wrt to the detector surface
- Charge collection efficiency as a function of the bulk depth
  - (Analog readout)

# The project



“Simulation of Heavily Irradiated Silicon Pixel Sensors and Comparison with Test Beam Measurements”

V. Chiochia et al., Nuclear Science, IEEE Transactions on, vol.52, no.4, pp. 1067- 1075, Aug. 2005

- Use this technique to perform  $\sim 1 \mu\text{m}$  resolved charge collection profiles

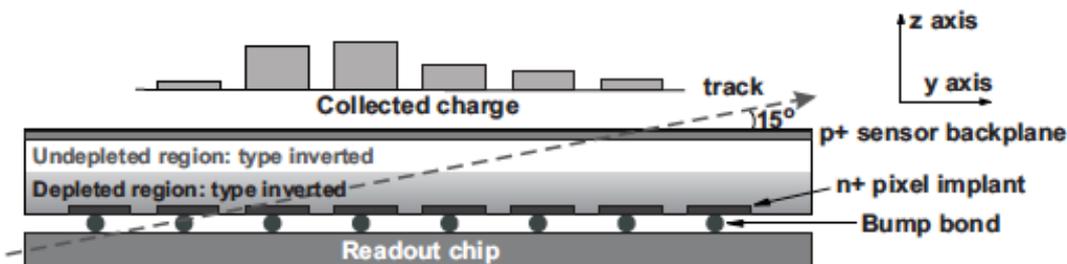


Fig. 2

THE GRAZING ANGLE TECHNIQUE FOR DETERMINING CHARGE COLLECTION PROFILES. THE CLUSTER LENGTH IS PROPORTIONAL TO THE DEPTH OVER WHICH CHARGE IS COLLECTED.

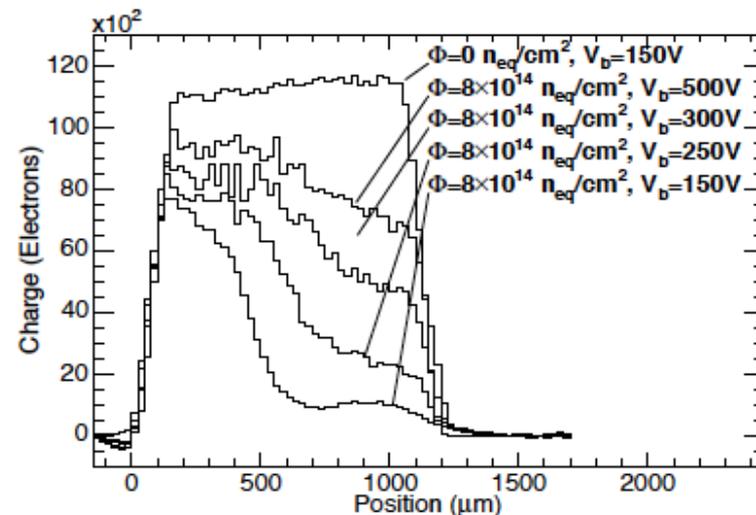
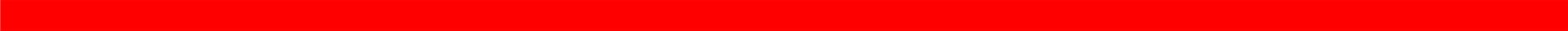


Fig. 3

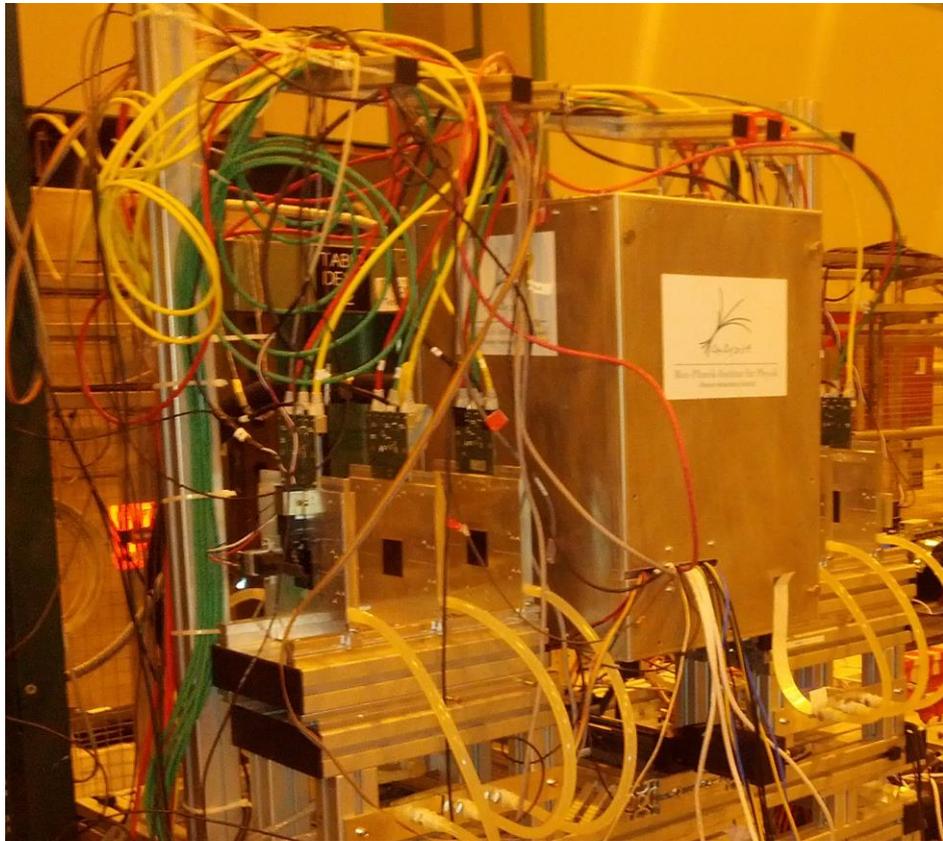
CHARGE COLLECTION PROFILES FOR AN IRRADIATED ( $\Phi = 8 \times 10^{14} \text{ N}_{\text{eq}}/\text{cm}^2$ ) AND AN UNIRRADIATED SENSOR ( $\Phi = 0 \text{ N}_{\text{eq}}/\text{cm}^2$ ) OPERATED AT SEVERAL BIAS VOLTAGES.

- Parameterization of the Electric Field in simulations
- Comparison data/simulation (next slides)

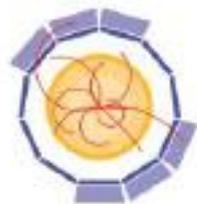
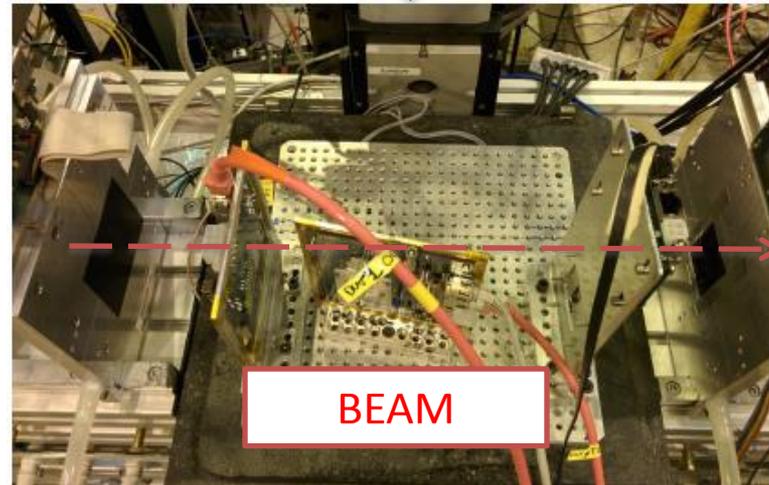


# THE TESTBEAM

# The testbeam: 20-27/10/2014



- CERN SPS H6B experimental hall
- 120 GeV  $\pi$
- Eudet/Aida telescope
- 2 Devices Under Test in the box



AIDA

# Testbeam report

Telescope moved from PS to SPS only few days before the testbeam start

- not fully unpacked/cabled
- had to finalize telescope setup, incl. network

Beam setup

- long stops for problems (mainly in PS) plus long MD/TS (2d) in 2<sup>nd</sup> week
- beamfile was wrong → beam pointing downward by  $\sim 10^{-2}$  rad → low trigger rate for 1.5d

Plus some unexpected problems

- LV cables for DCS system didn't work → needed to find enough PS channels
- parts of the mechanics missing → had to adapt schedule → lost one day
- USBPix behaved differently from lab tests, i.e. didn't work
- Several power-cuts in the experimental area
- Unexpected network resets

Almost no data taken 😞 (maybe some data from a parasitic run later this month)



# **THE SIMULATIONS STUDIES**

# Simulation studies

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- In parallel with the testbeam preparation and running (!) the program of simulation was carried on
- MPI and TU Dortmund had a total of 5 samples to be measured
- Several radiation damage models have been tested

# Samples

type	Name (and group)	Thickness ( $\mu\text{m}$ )	Irradiation type & Fluence ( $10^{15} n_{\text{eq}}/\text{cm}^2$ )
N-on-p	MPI_VTT-AM4-NP1-8-E4 (MPI)	100	KIT p's - 5
N-on-p	MPI_VTT-NP2-20-E4 (MPI)	200	LUB n's - 6
N-on-p	MPI_VTT-NP1-4-E5 (MPI)	100	LUB n's - 2
N-on-n	DO_FZ (TU DO)	200	PSI $\pi$ 's - 0.416
N-on-n	DO_MCz (TU DO)	285	PSI $\pi$ 's - 0.416

# P-bulk: irradiation models

## Petasecca p-bulk

Type	Energy (eV)	Defect	$\sigma_e(\text{cm}^2)$	$\sigma_h(\text{cm}^2)$	$\eta(\text{cm}^{-1})$
→ Acceptor	$E_C - 0.42$	VV	$2.0 \times 10^{-15}$	$2.0 \times 10^{-14}$	1.613
Acceptor	$E_C - 0.46$	VVV	$5.0 \times 10^{-15}$	$5.0 \times 10^{-14}$	0.9
→ Donor	$E_V + 0.36$	$C_iO_i$	$2.5 \times 10^{-14}$	$2.5 \times 10^{-15}$	0.9

## Pennicard p-bulk

Type	Energy (eV)	Defect	$\sigma_e(\text{cm}^2)$	$\sigma_h(\text{cm}^2)$	$\eta(\text{cm}^{-1})$
→ Acceptor	$E_C - 0.42$	VV	$9.5 \times 10^{-15}$	$9.5 \times 10^{-14}$	1.613
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→ Donor	$E_V + 0.36$	$C_iO_i$	$3.23 \times 10^{-13}$	$3.23 \times 10^{-14}$	0.9

# N-bulk irradiation models

## Petasecca model for N-type

Level	Ass.	$\sigma_{n,p}$ (cm <sup>2</sup> ) Exp.[2,9]	$\sigma_n$ (cm <sup>2</sup> )	$\sigma_p$ (cm <sup>2</sup> )	$\eta$ (cm <sup>-1</sup> )
Ec-0.42eV	VV <sup>(/0)</sup>	$2 \times 10^{-15}$	$2 \times 10^{-15}$	$1.2 \times 10^{-14}$	13
Ec-0.50eV	VVO(?)	$5 \times 10^{-15}$	$5 \times 10^{-15}$	$3.5 \times 10^{-14}$	0.08
Ev+0.36eV	C <sub>i</sub> O <sub>i</sub>	$2.5 \times 10^{-15}$	$2 \times 10^{-18}$	$2.5 \times 10^{-15}$	1.1

Plus: fluence dependent carrier lifetime

## EVL model for N-type

Trap	E (eV)	$g_{\text{int}}$ (cm <sup>-1</sup> )	$\sigma_e$ (cm <sup>2</sup> )	$\sigma_h$ (cm <sup>2</sup> )
Donor	$E_V + 0.48$	6	$1 \times 10^{-15}$	$1 \times 10^{-15}$
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Same levels as EVL model

## Chiochia model for N-type

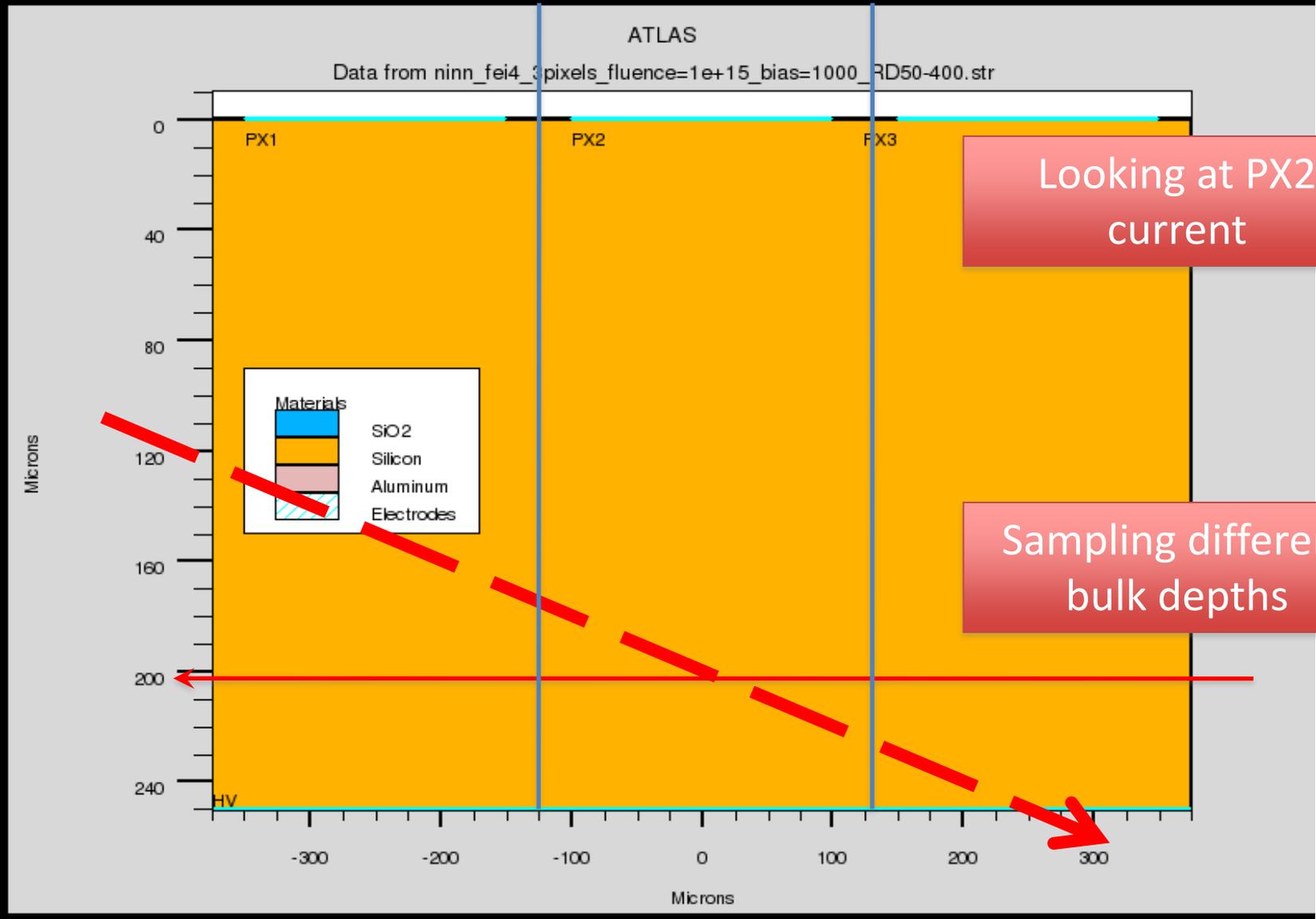
$\Phi$ (n <sub>eq</sub> /cm <sup>2</sup> ) ( $\times 10^{14}$ )	$N_A$ (cm <sup>-3</sup> ) ( $\times 10^{15}$ )	$N_D$ (cm <sup>-3</sup> ) ( $\times 10^{15}$ )	$\sigma_e^{A/D}$ (cm <sup>2</sup> ) ( $\times 10^{-15}$ )	$\sigma_h^A$ (cm <sup>2</sup> ) ( $\times 10^{-15}$ )	(cm <sup>2</sup> ) $\sigma_h^D$ ( $\times 10^{-15}$ )
0.5	0.19	0.25	6.60	1.65	6.60
2	0.68	1.0	6.60	1.65	6.60
5.9	1.60	4.0	6.60	1.65	1.65

# Charge profile simulations

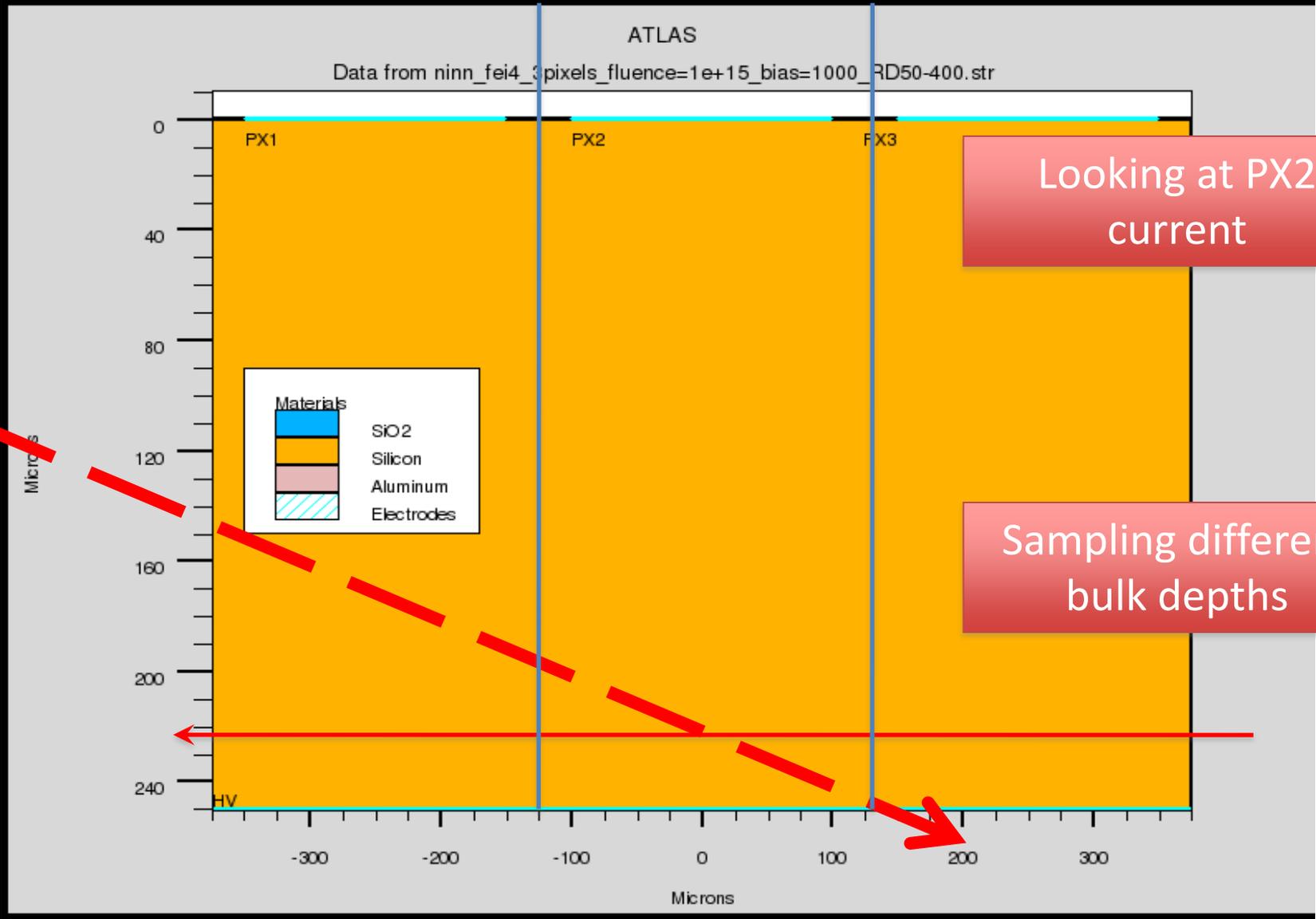
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- Tracks impinging at  $15^\circ$  wrt to the sensor's surface
- Scan along the surface in  $10\ \mu\text{m}$  steps

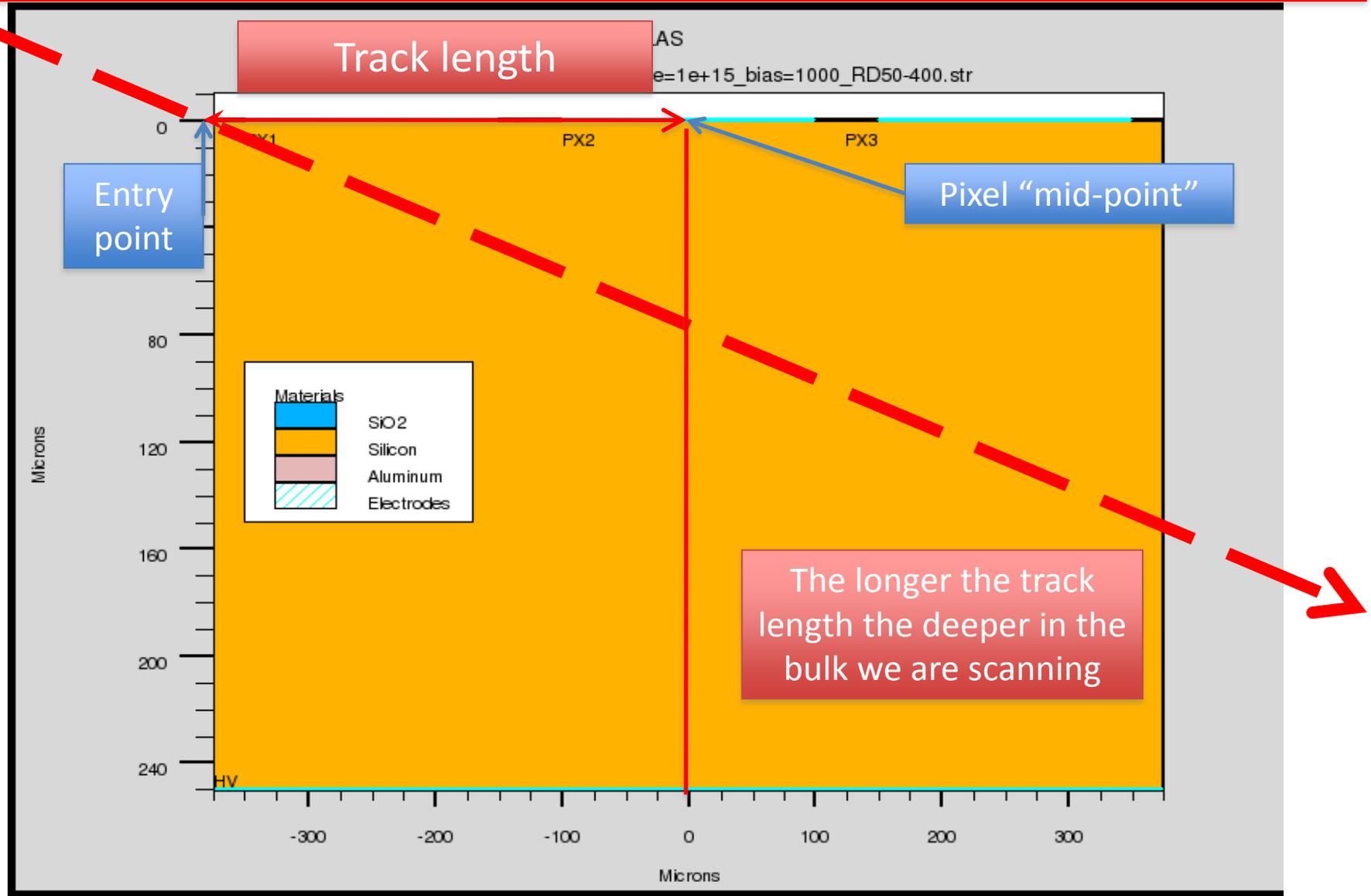
# Scanning the bulk depth



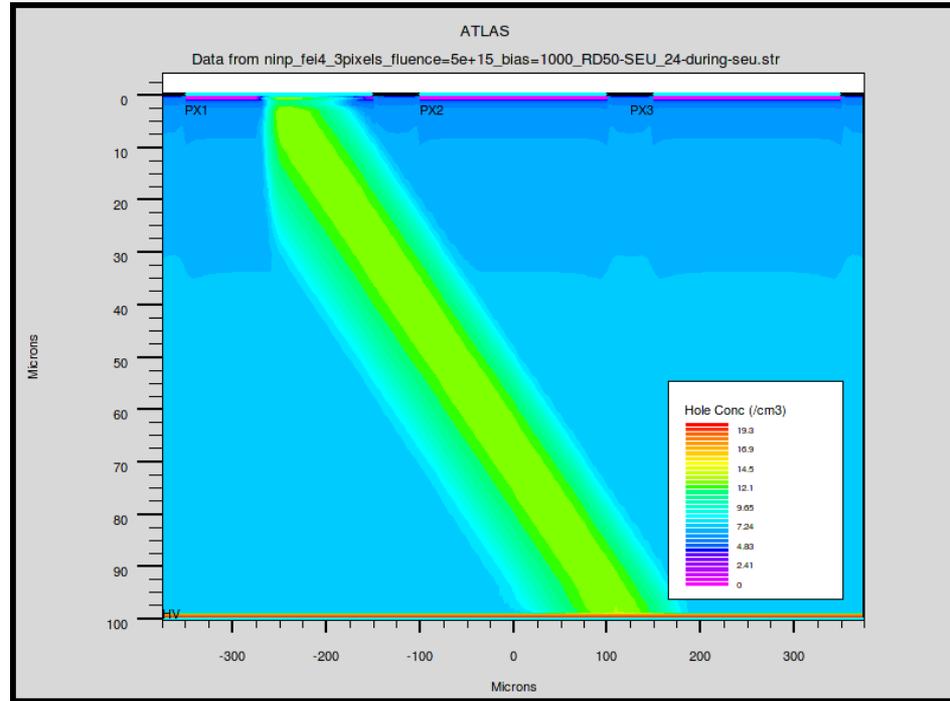
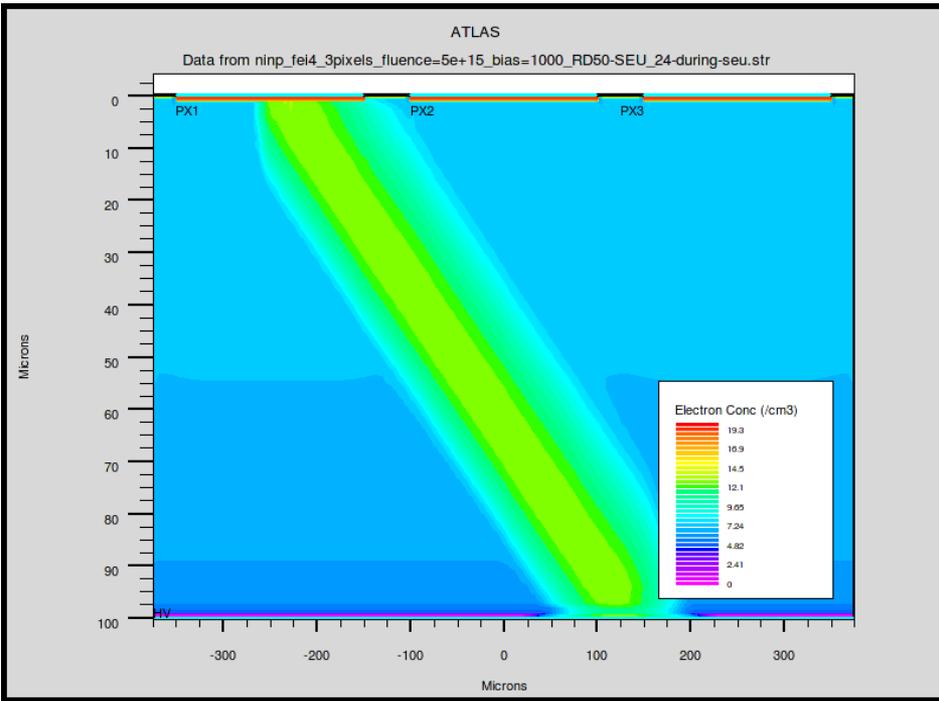
# Scanning the bulk depth



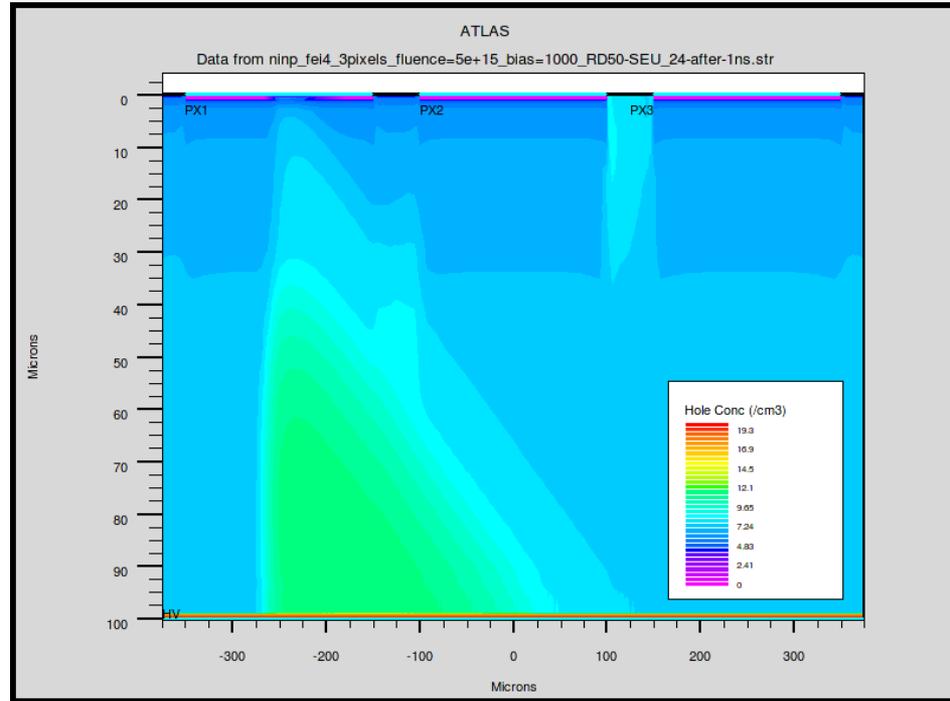
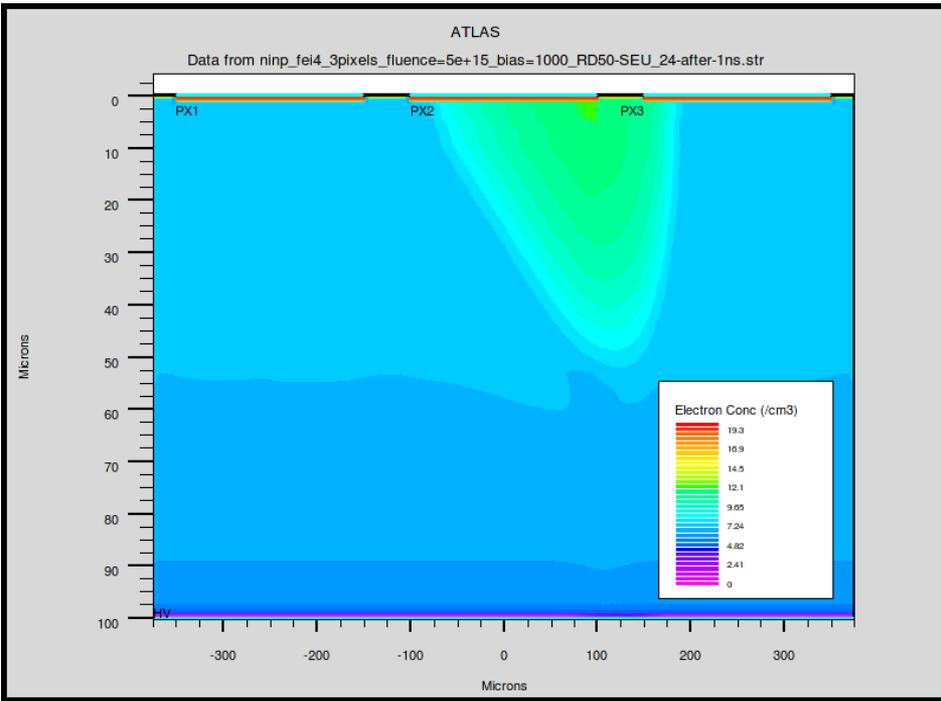
# Scanning the bulk depth



# Carrier concentration during the hit



# Carrier concentration 1 ns after the hit





# **N-ON-P RESULTS**

# N-on-p samples

type	Name (and group)	Thickness ( $\mu\text{m}$ )	Irradiation type & Fluence ( $10^{15} n_{\text{eq}}/\text{cm}^2$ )
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N-on-p	MPI_VTT-NP1-4-E5 (MPI)	100	LUB n's - 2
N-on-n	DO_FZ (TU DO)	200	PSI $\pi$ 's - 0.416
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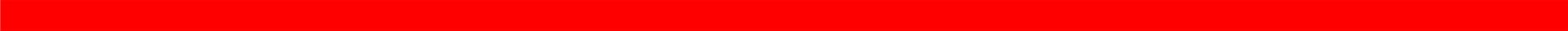
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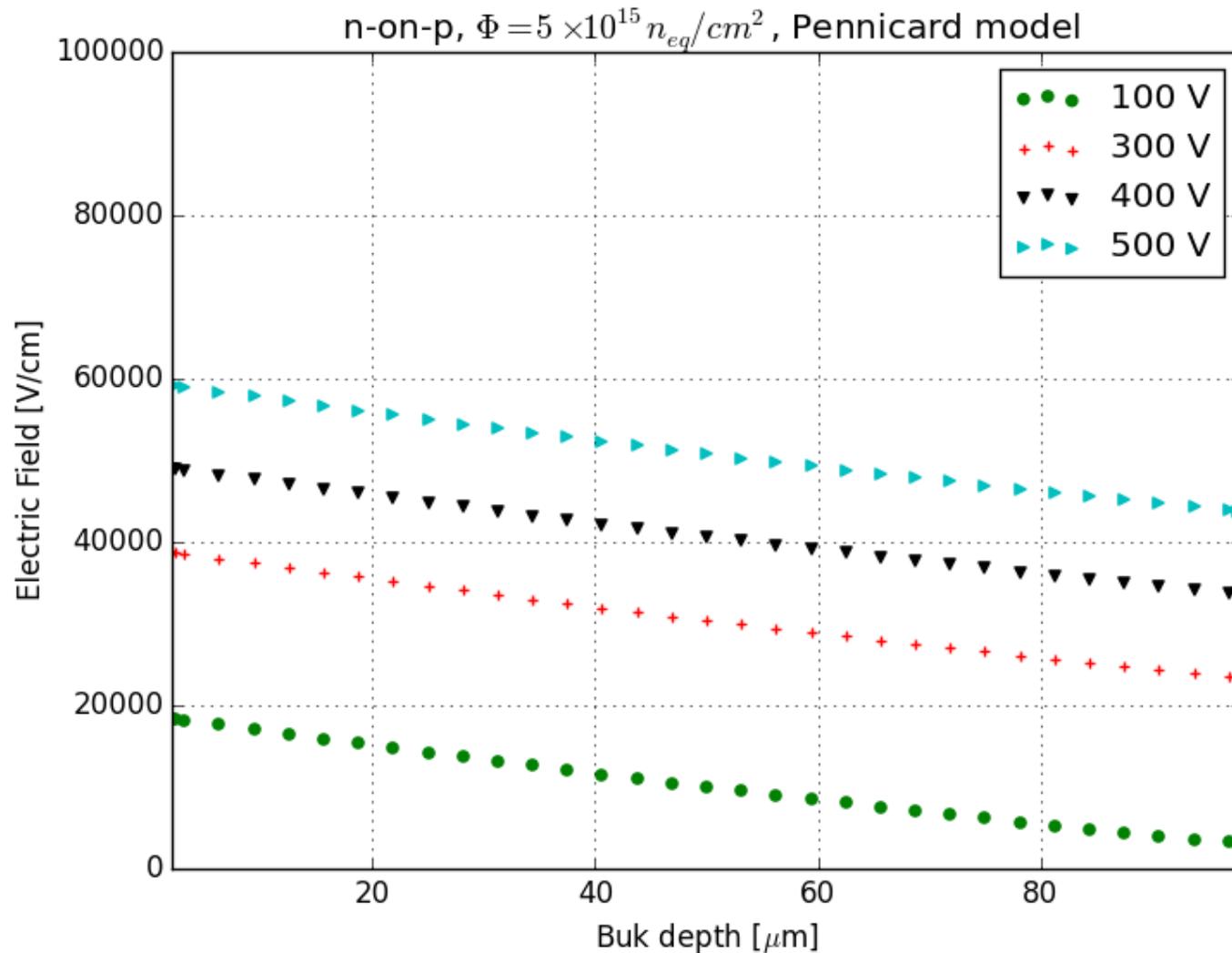
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Type	Energy (eV)	Defect	$\sigma_e(\text{cm}^2)$	$\sigma_h(\text{cm}^2)$	$\eta(\text{cm}^{-1})$
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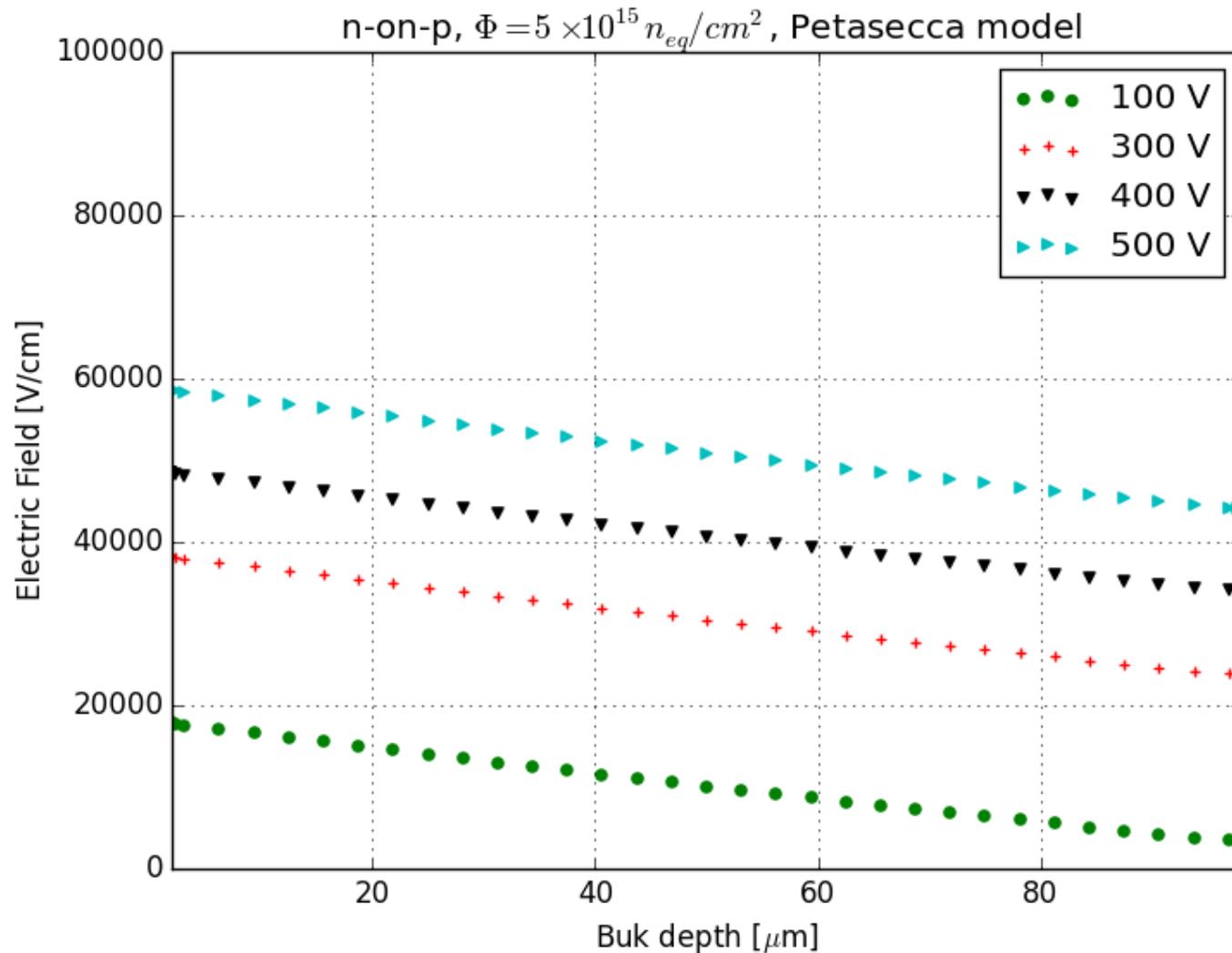


# THIN N-ON-P SENSOR

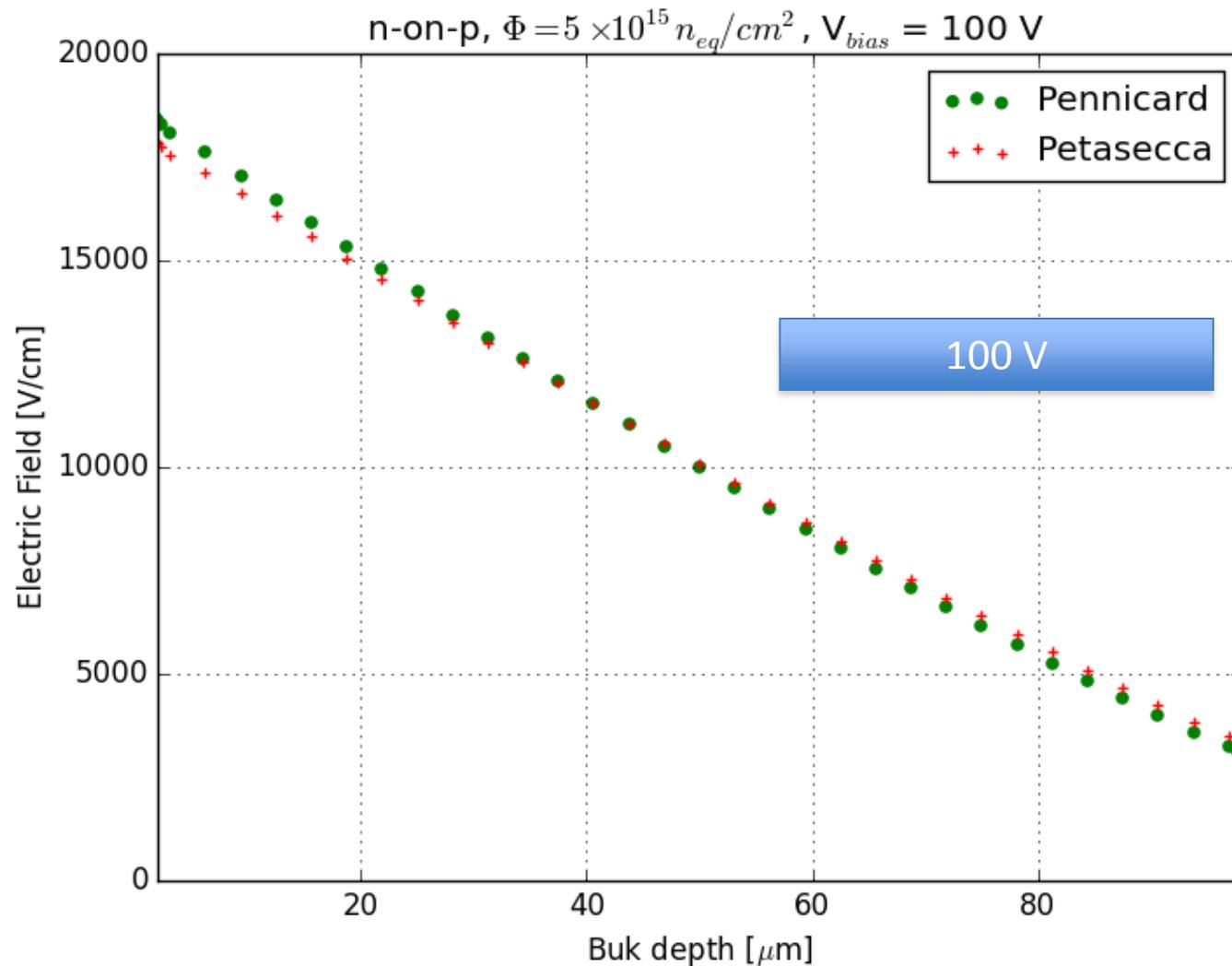
# MPI\_VTT-AM4-NP1-8-E4 - Electric field profile



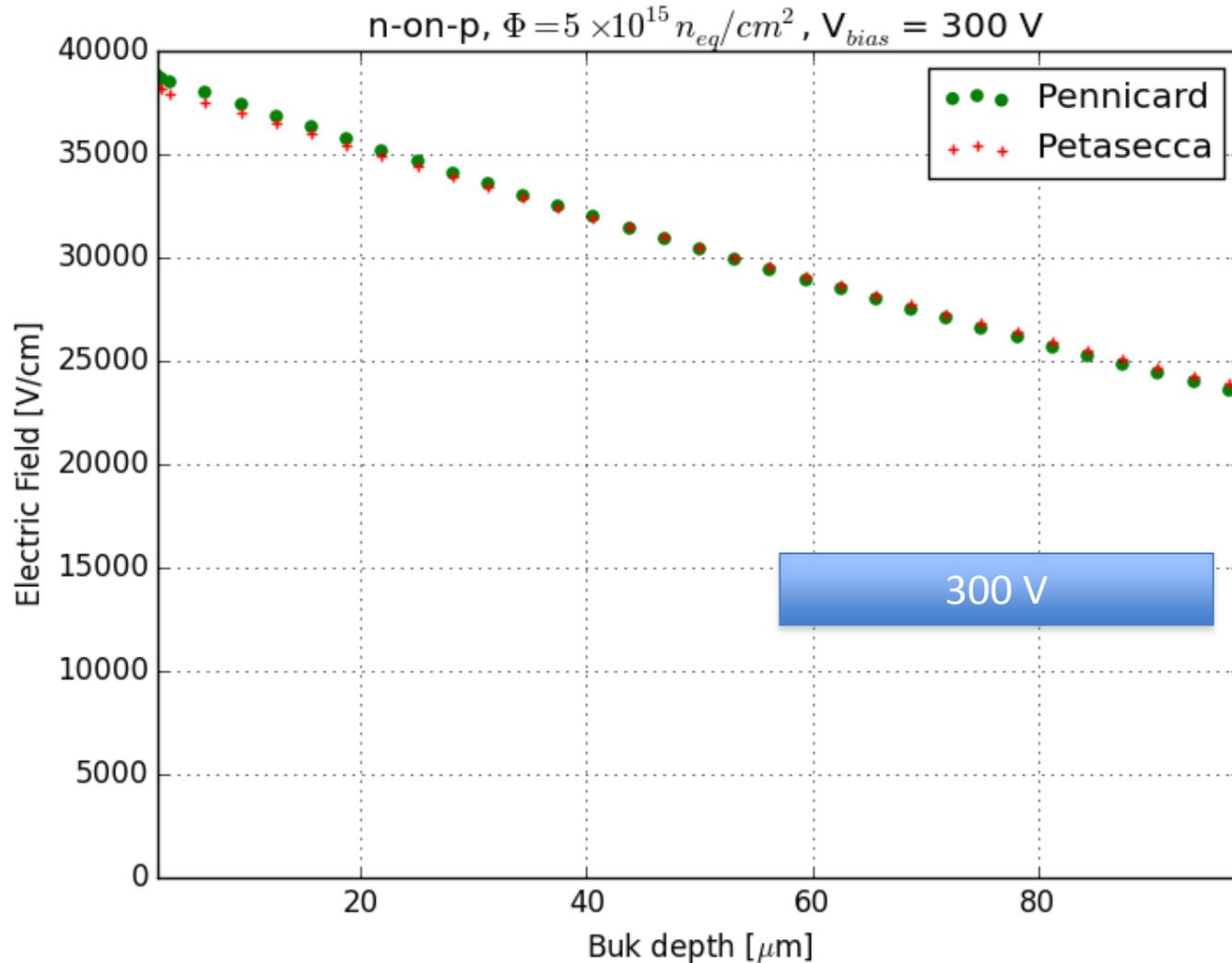
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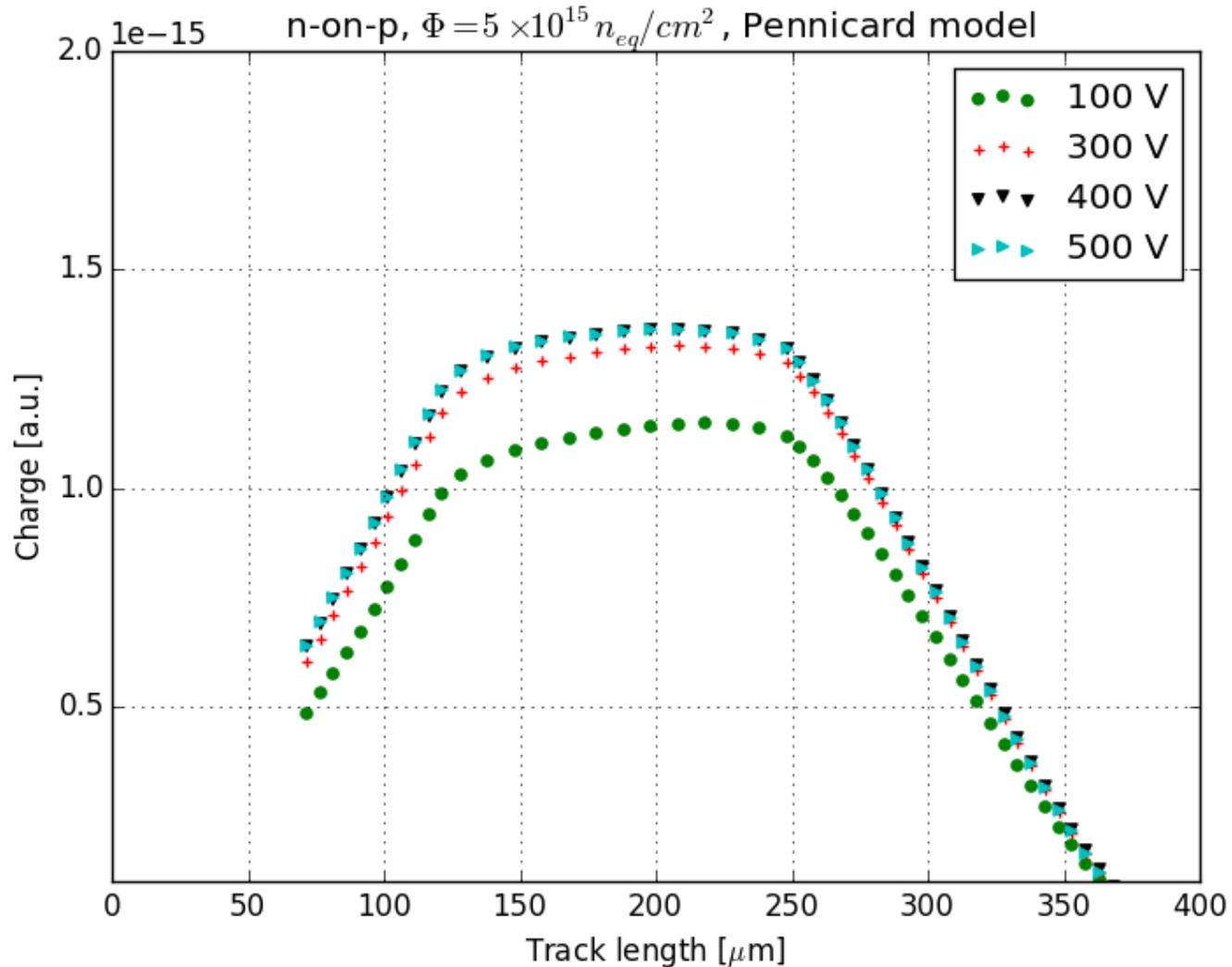
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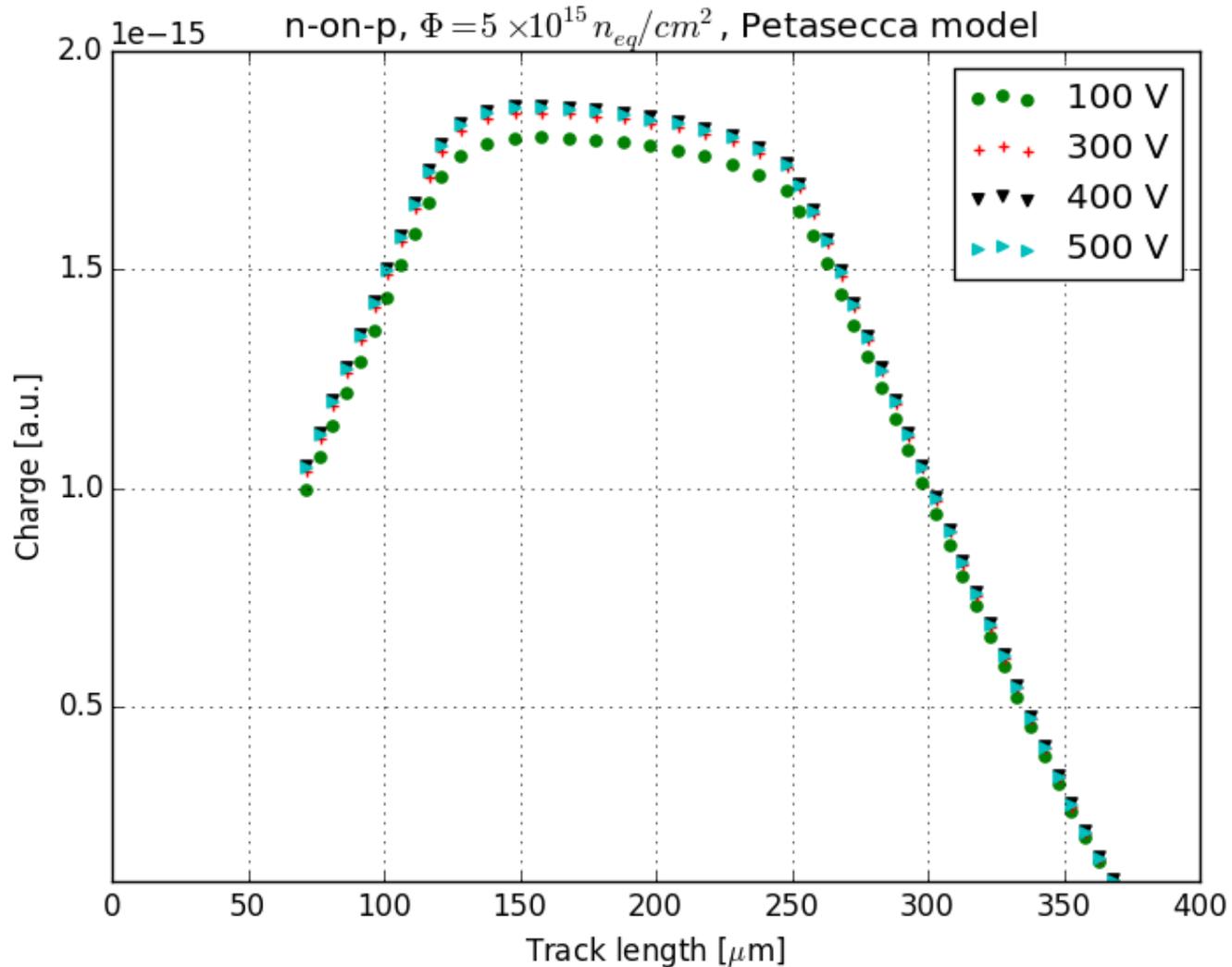
# MPI\_VTT-AM4-NP1-8-E4 – electric field



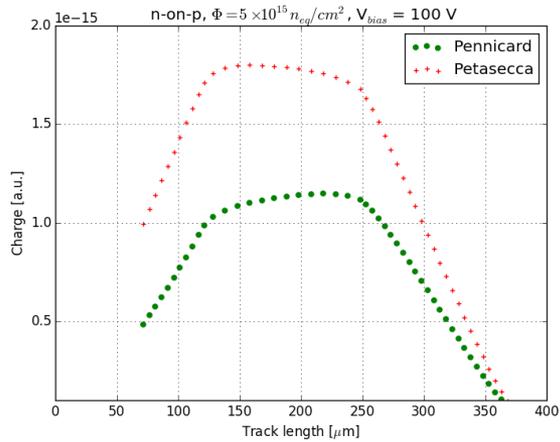
# MPI\_VTT-AM4-NP1-8-E4 - charge profile



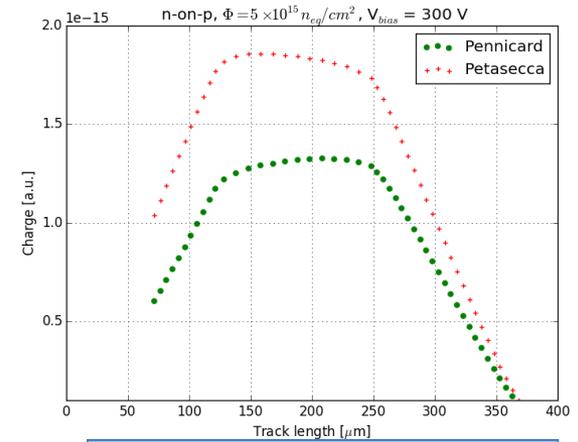
# MPI\_VTT-AM4-NP1-8-E4 - charge profile



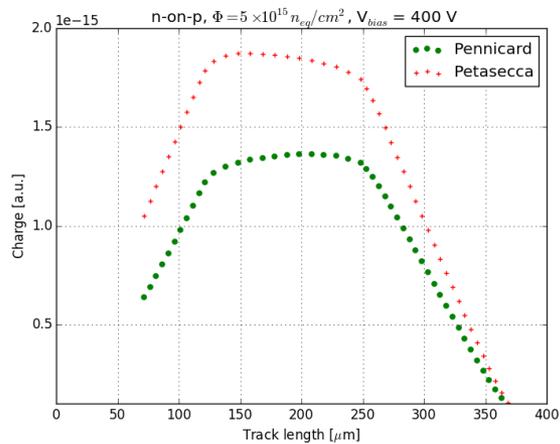
# MPI\_VTT-AM4-NP1-8-E4 – charge vs bias



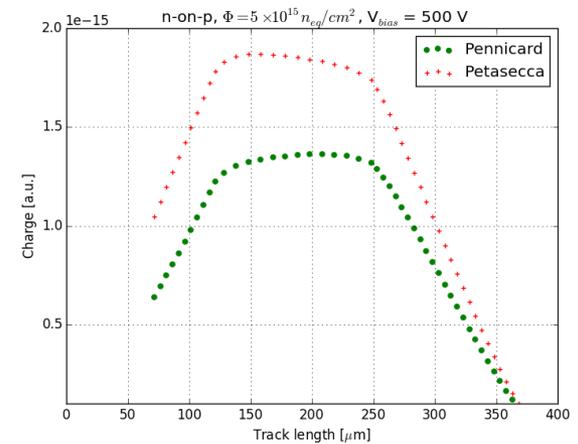
100 V



300 V

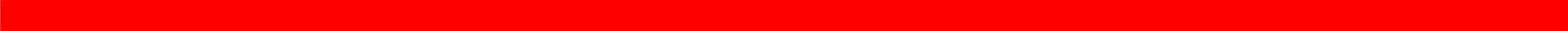


400 V



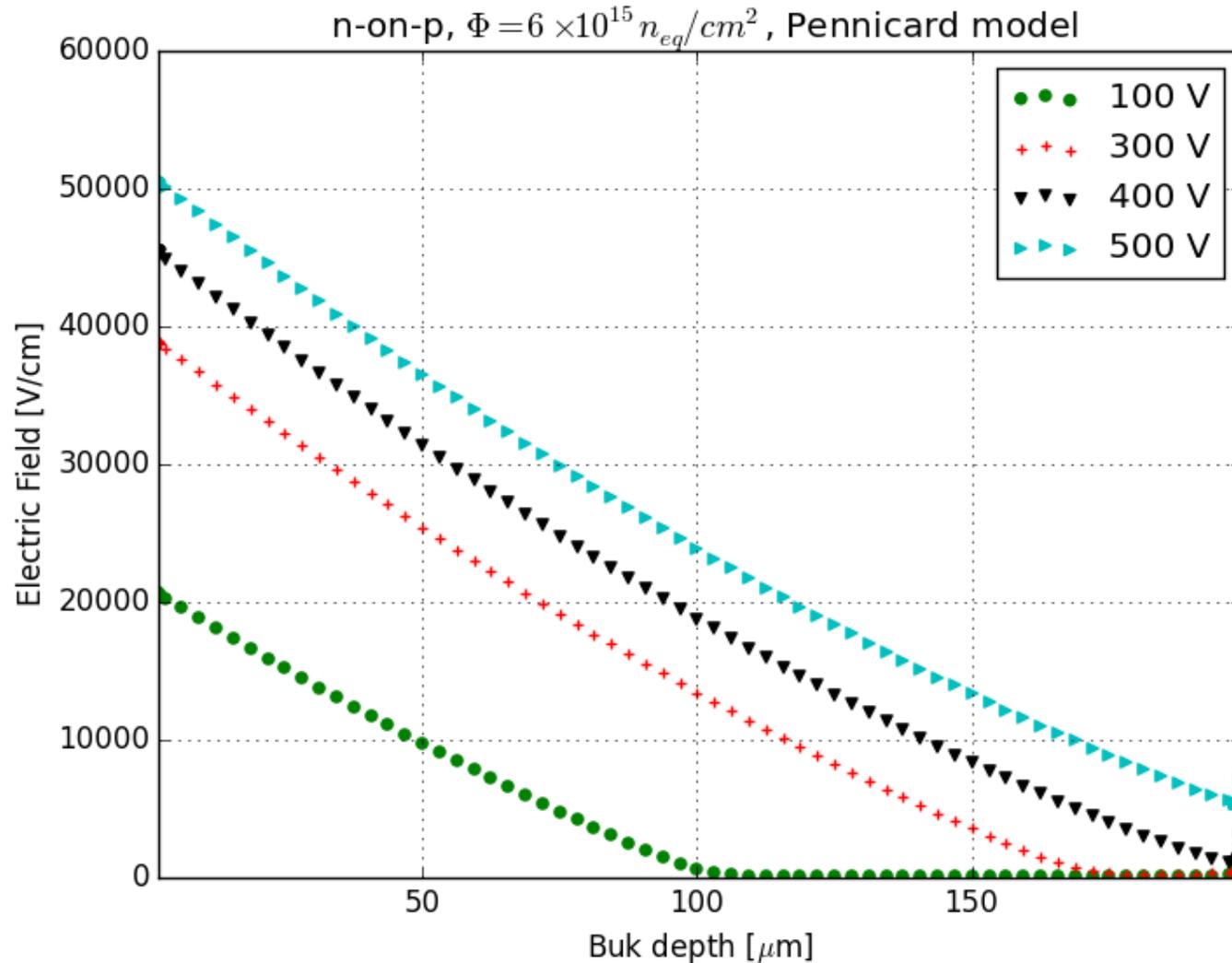
500 V

● Pennicard  
+ Petasecca

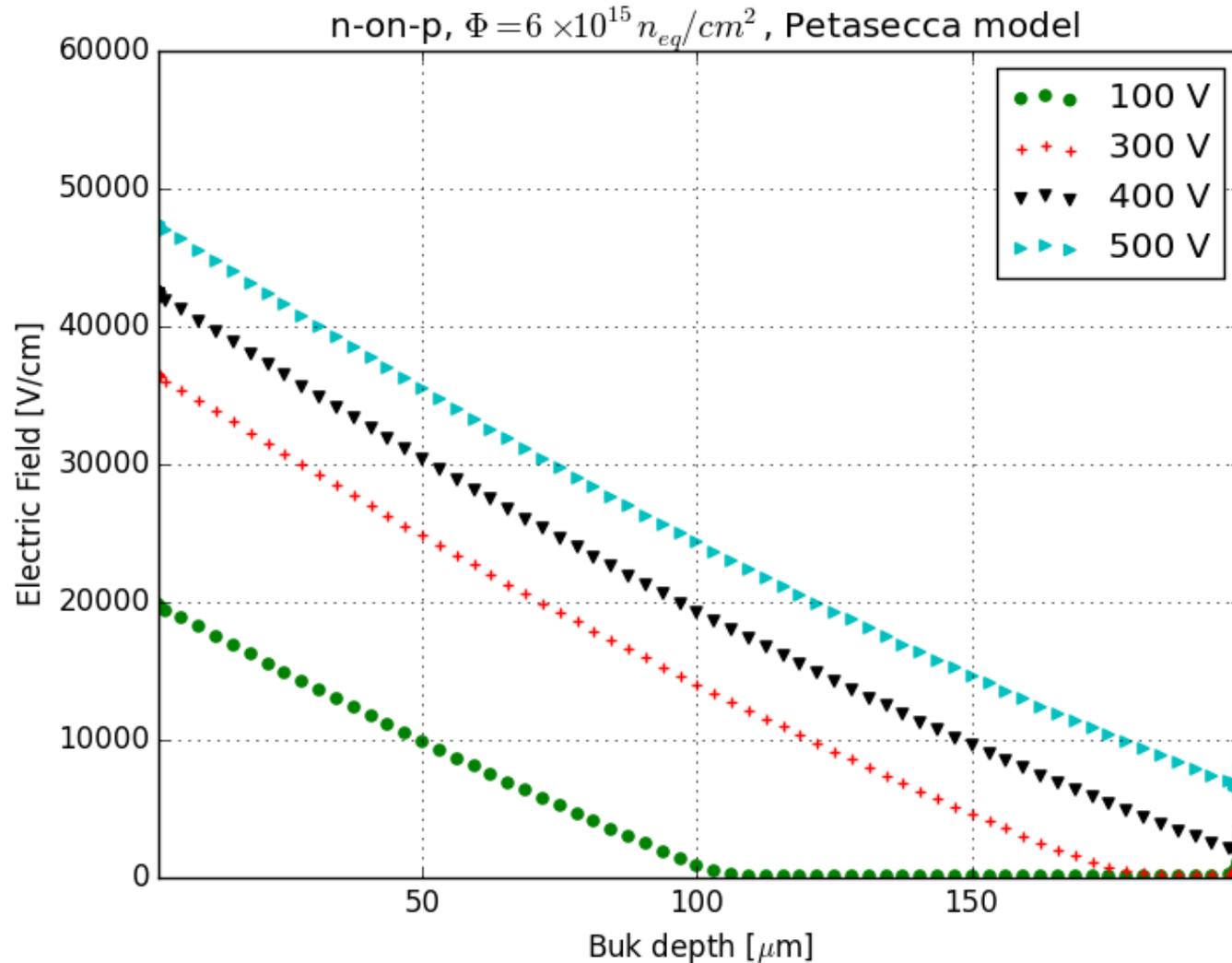


# **THICK N-ON-P SENSOR**

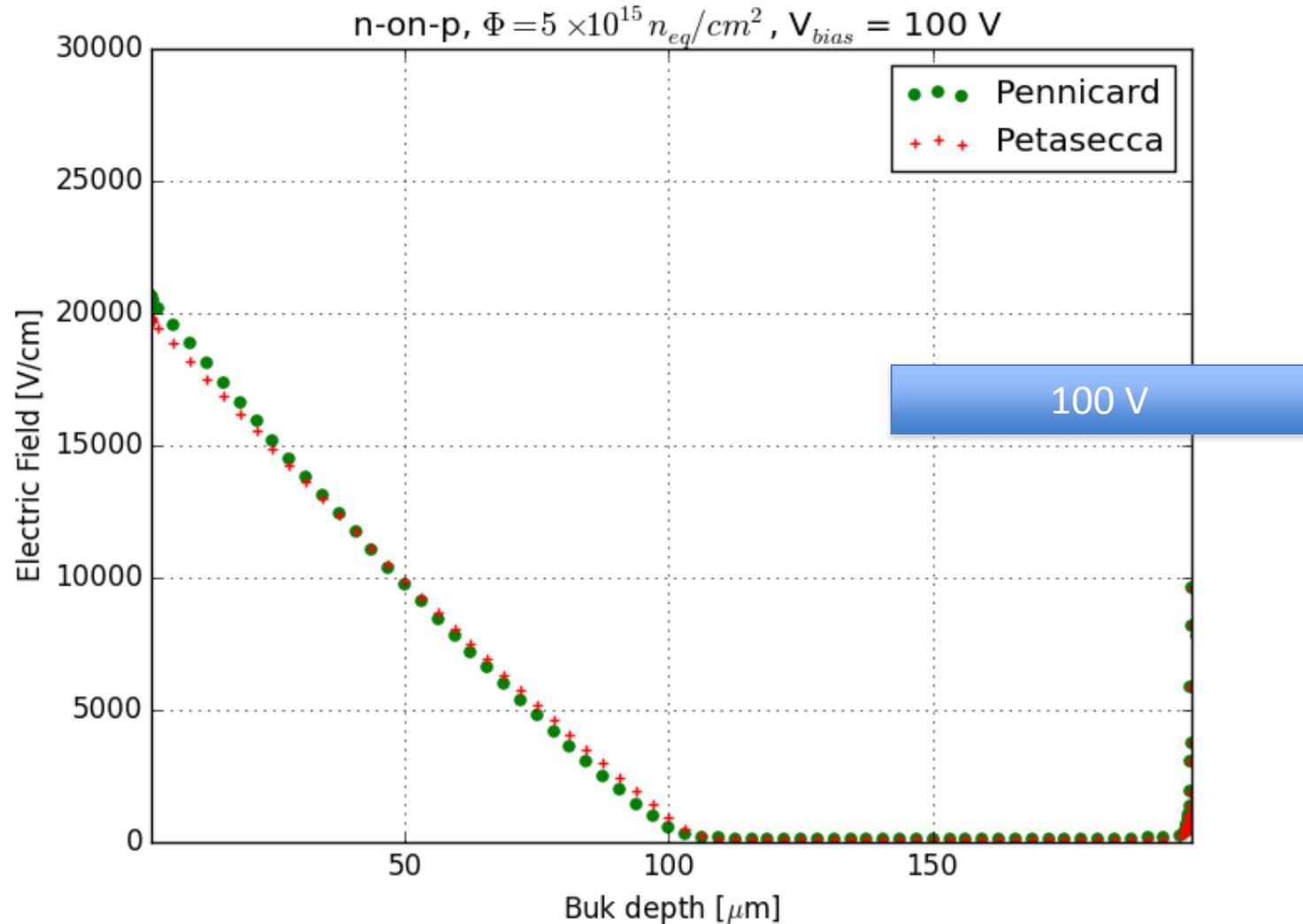
# MPI\_VTT-NP2-20-E4 - Electric field profile



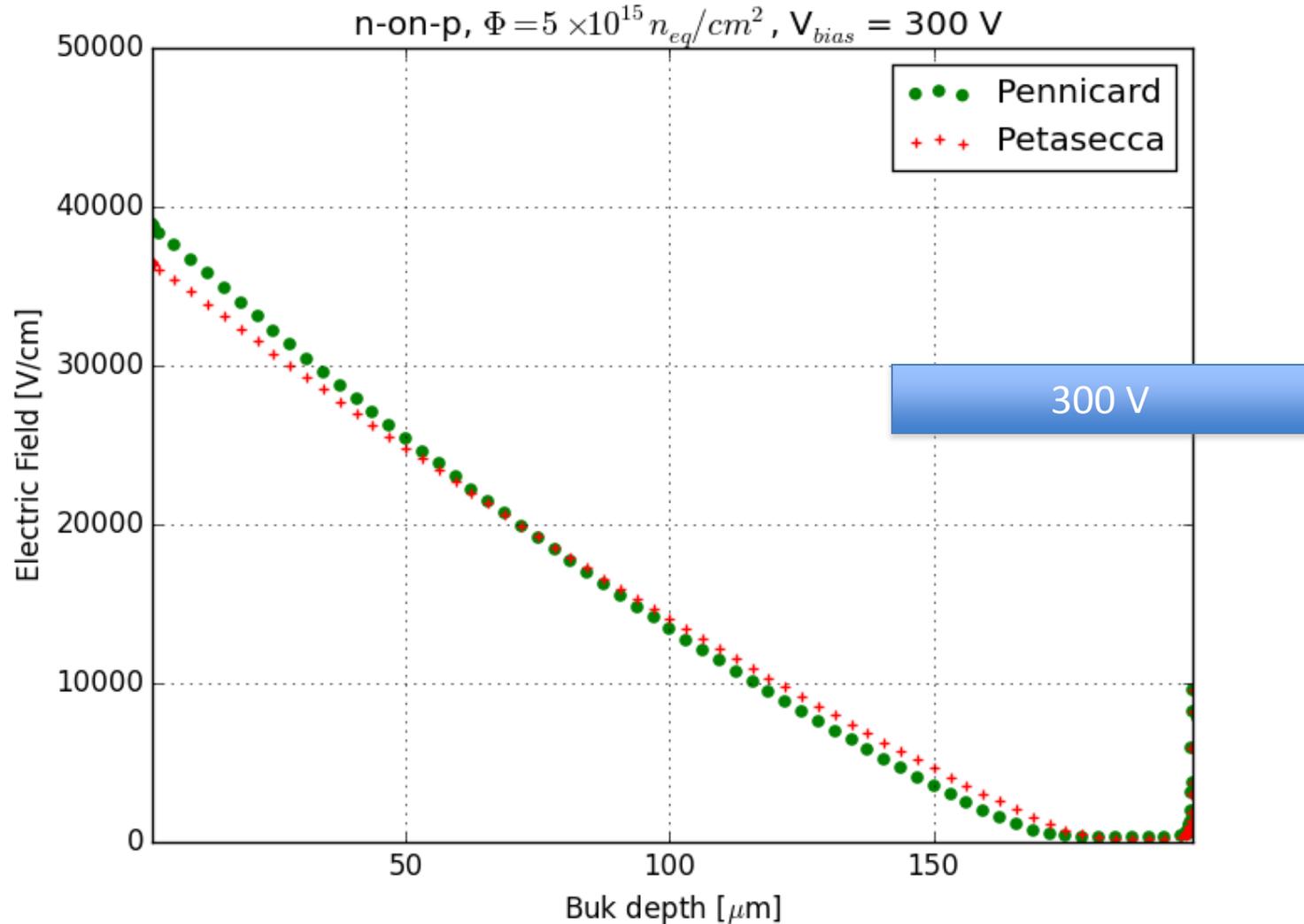
# MPI\_VTT-NP2-20-E4 - Electric field profile



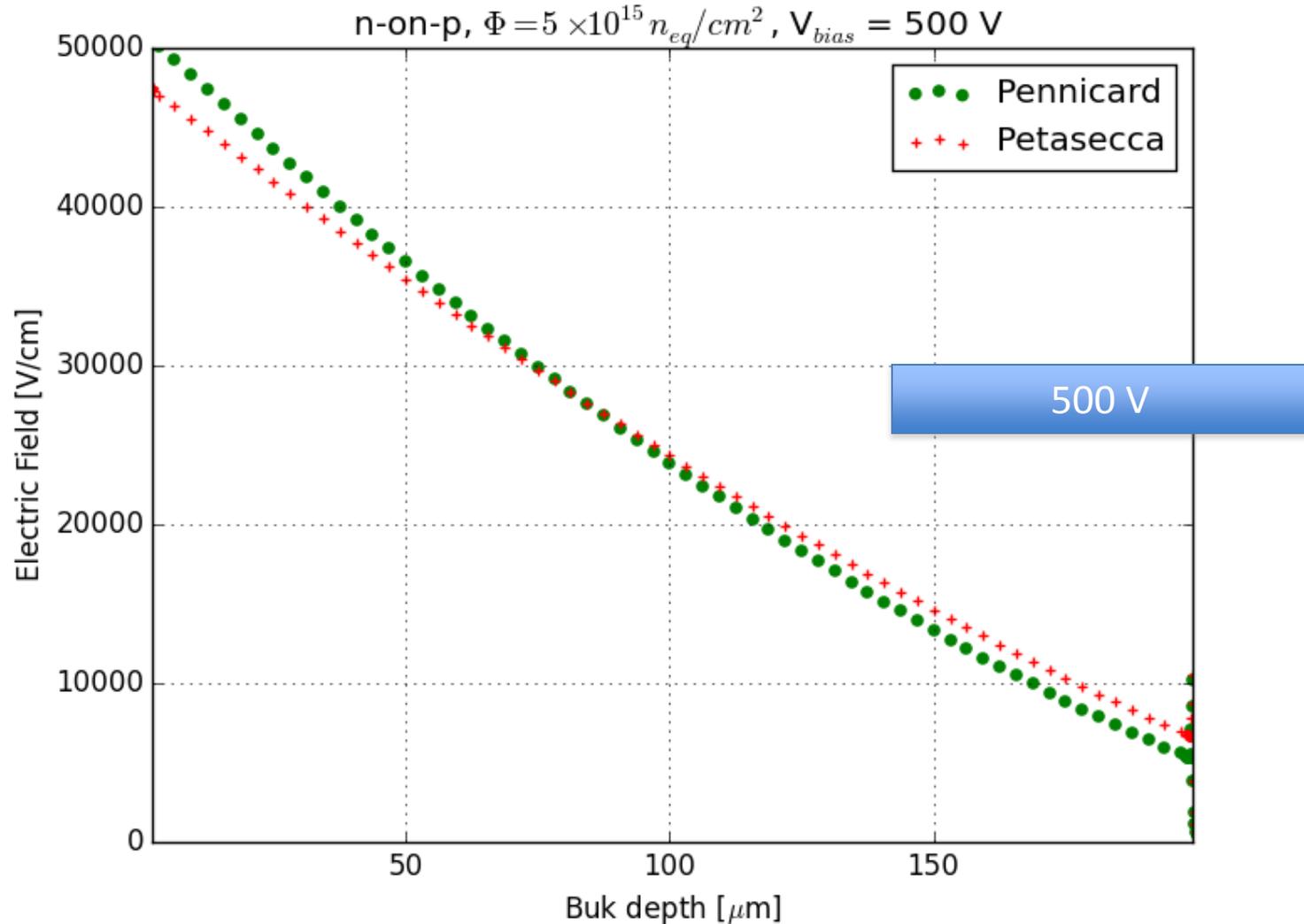
# MPI\_VTT-NP2-20-E4 - Electric field comparison



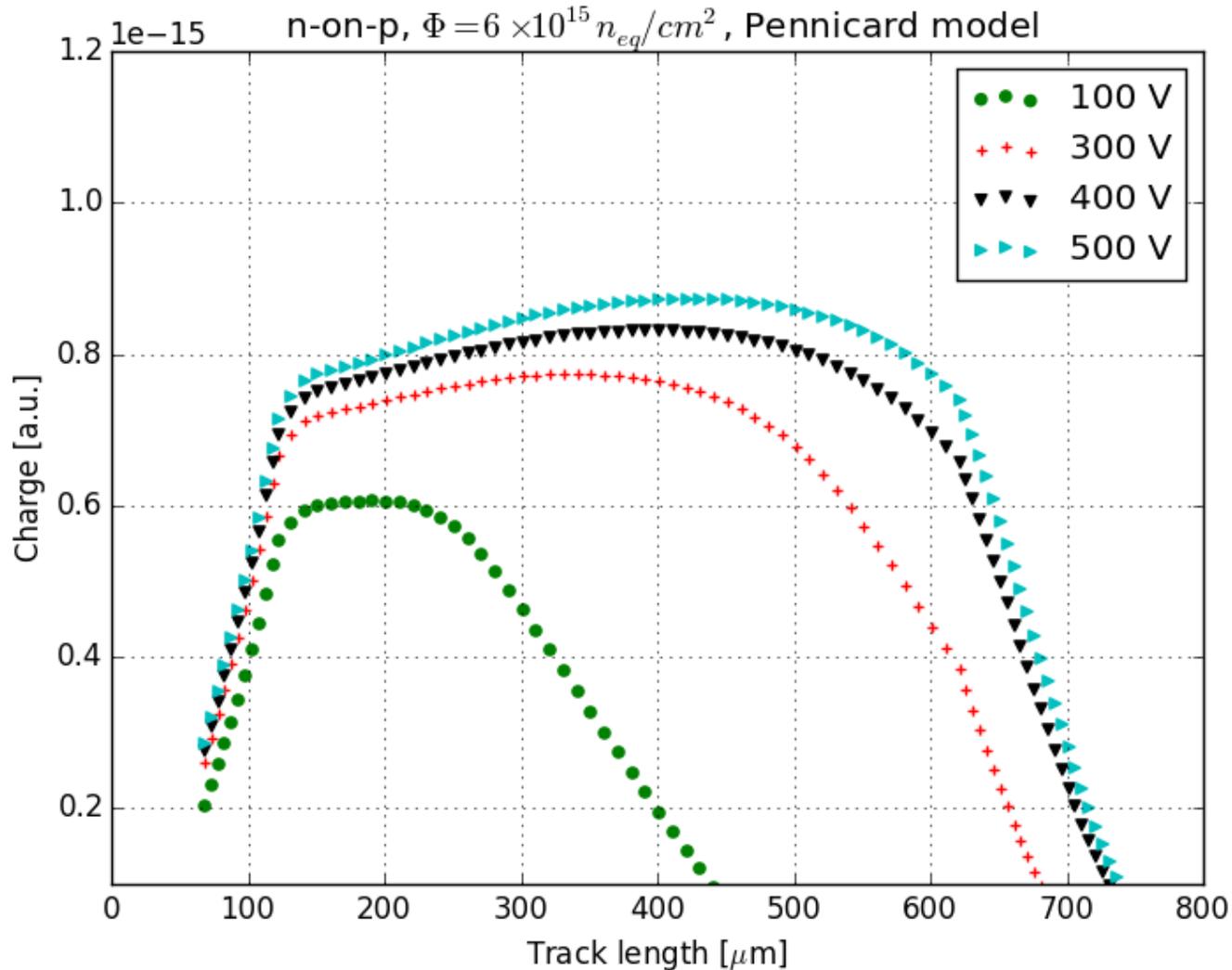
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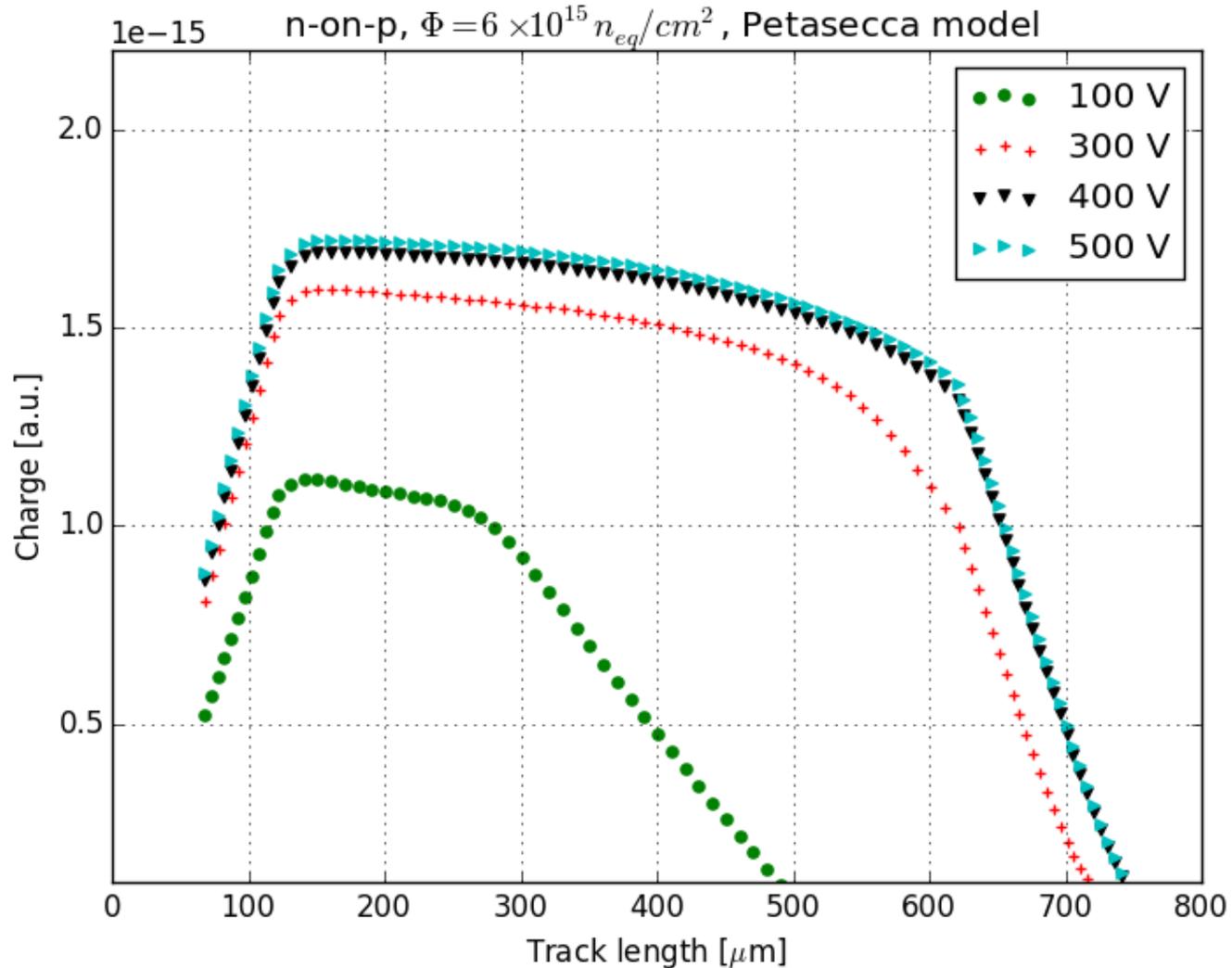
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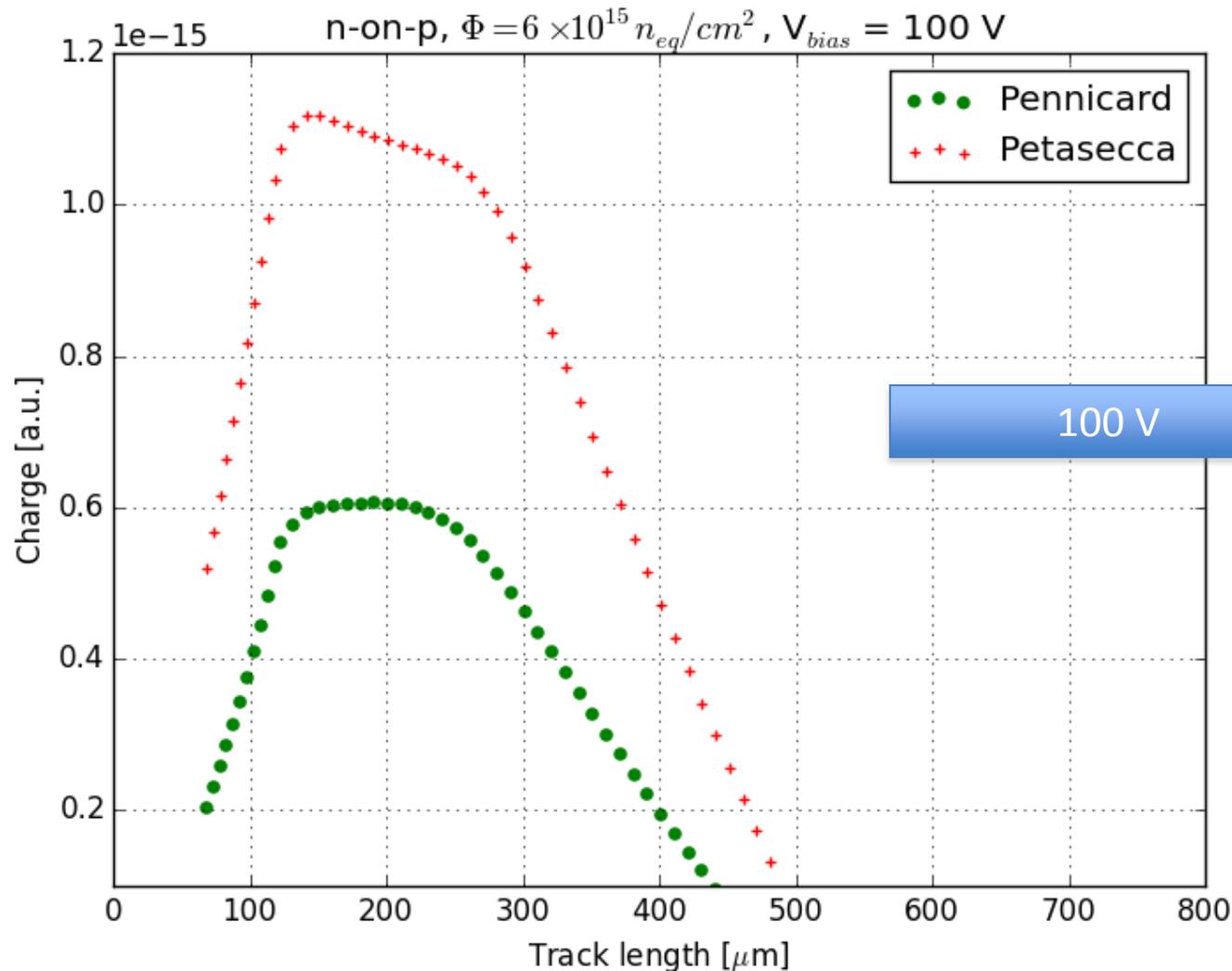
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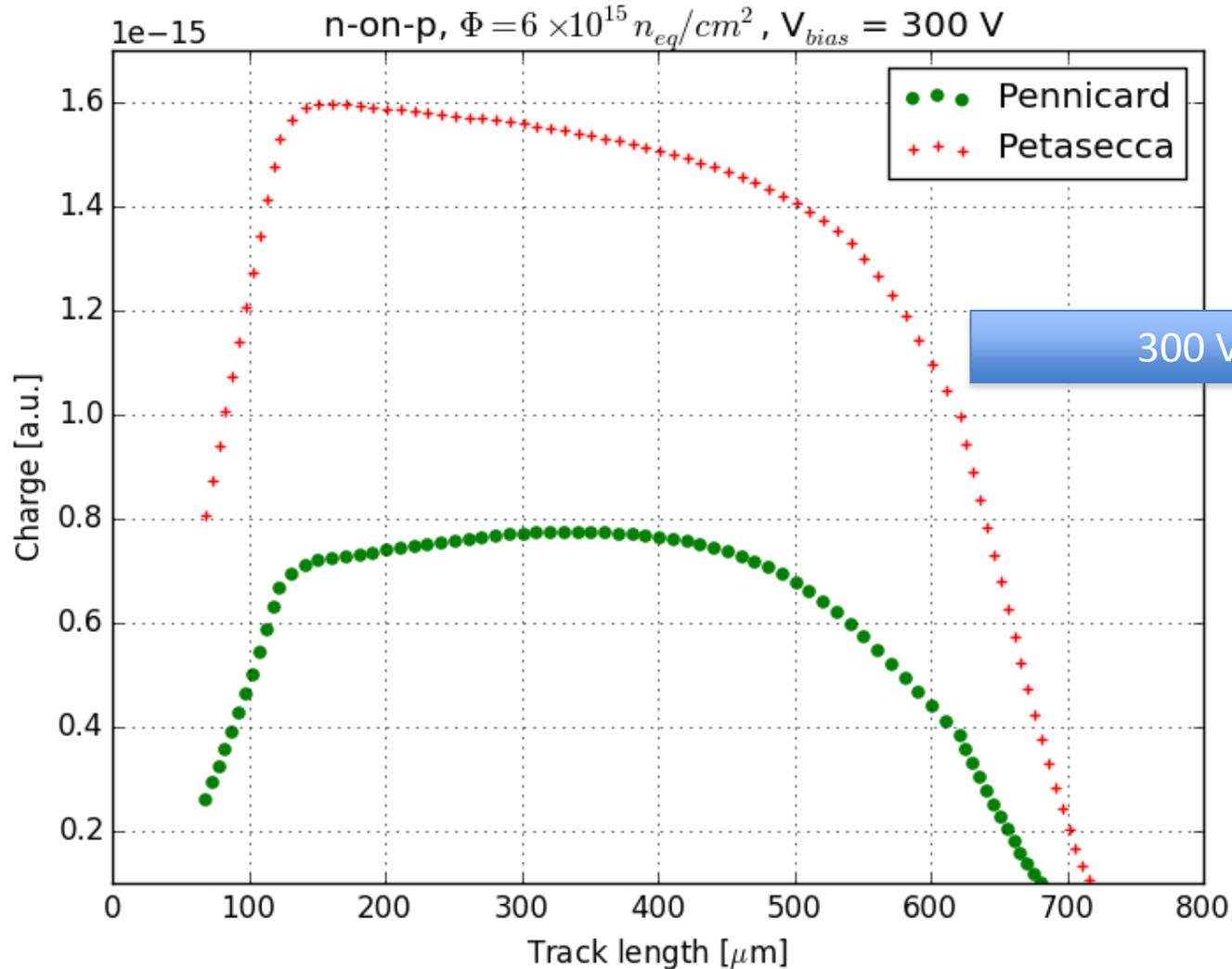
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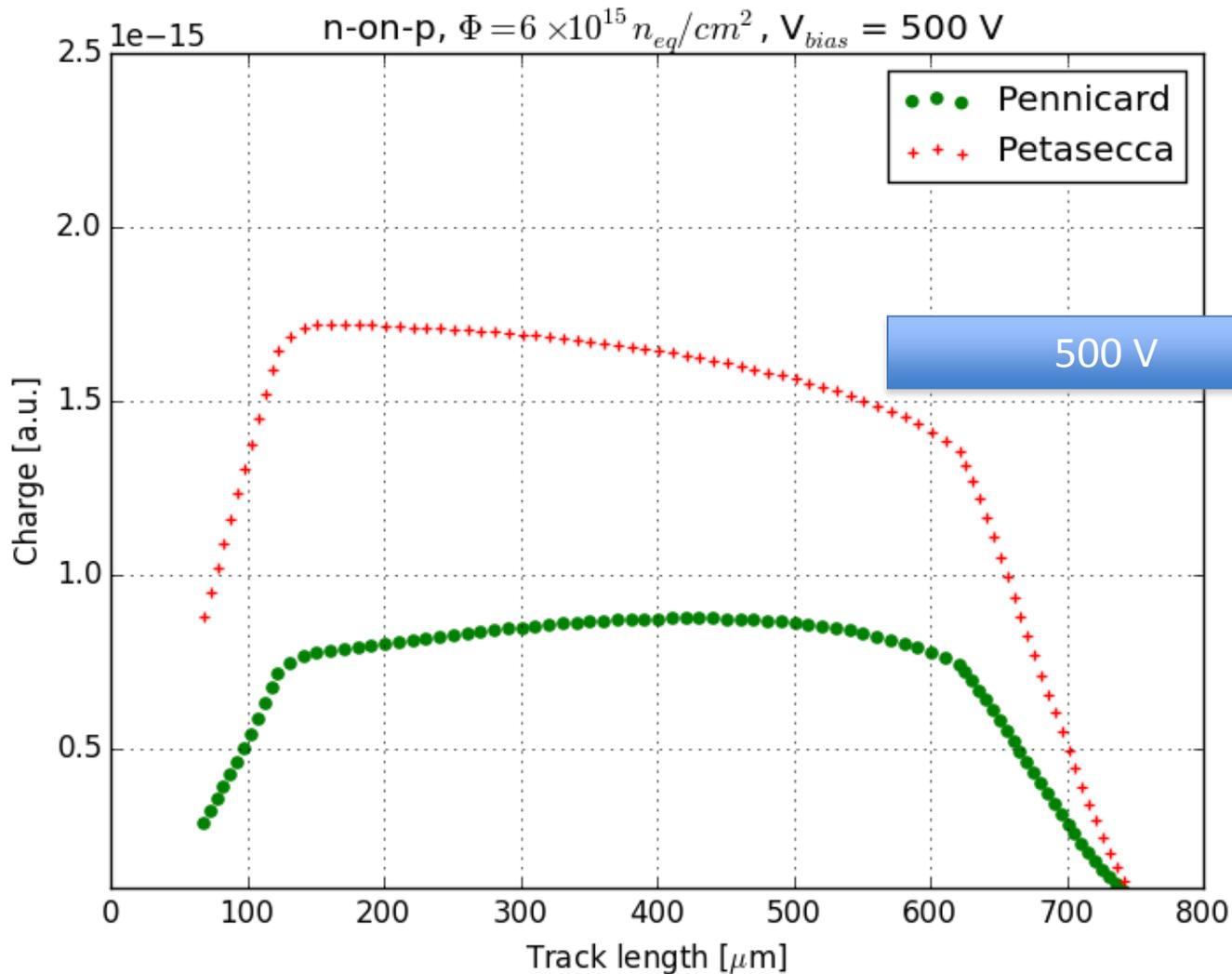
# MPI\_VTT-NP2-20-E4 – Charge profile comparison



# MPI\_VTT-NP2-20-E4 – Charge profile comparison



# MPI\_VTT-NP2-20-E4 – Charge profile comparison



# Discussion of n-on-p results

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- The two models predict very similar electric field profiles
- On the contrary the two models predict different charge profiles
- The reason for this is apparently the different values for (some of the) emission/capture cross-section
- To confirm/discard a model good charge calibration for data and simulation are needed!



# **N-ON-N RESULTS**

# N-on-n samples

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N-on-p	MPI_VTT-NP2-20-E4 (MPI)	200	LUB n's - 6
N-on-p	MPI_VTT-NP1-4-E5 (MPI)	100	LUB n's - 2
N-on-n	DO_FZ (TU DO)	200	PSI $\pi$ 's - 0.416
N-on-n	DO_MCz (TU DO)	285	PSI $\pi$ 's - 0.416

# Reminder: N-bulk irradiation models

## Petasecca model for N-type

Level	Ass.	$\sigma_{n,p}$ (cm <sup>2</sup> ) Exp.[2,9]	$\sigma_n$ (cm <sup>2</sup> )	$\sigma_p$ (cm <sup>2</sup> )	$\eta$ (cm <sup>-1</sup> )
Ec-0.42eV	VV <sup>(/0)</sup>	$2 \times 10^{-15}$	$2 \times 10^{-15}$	$1.2 \times 10^{-14}$	13
Ec-0.50eV	VVO(?)	$5 \times 10^{-15}$	$5 \times 10^{-15}$	$3.5 \times 10^{-14}$	0.08
Ev+0.36eV	C <sub>i</sub> O <sub>i</sub>	$2.5 \times 10^{-15}$	$2 \times 10^{-18}$	$2.5 \times 10^{-15}$	1.1

Plus: fluence dependent carrier lifetime

## EVL model for N-type

Trap	E (eV)	$g_{int}$ (cm <sup>-1</sup> )	$\sigma_e$ (cm <sup>2</sup> )	$\sigma_h$ (cm <sup>2</sup> )
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Acceptor	$E_C - 0.525$	3.7	$1 \times 10^{-15}$	$1 \times 10^{-15}$

Same levels as EVL model

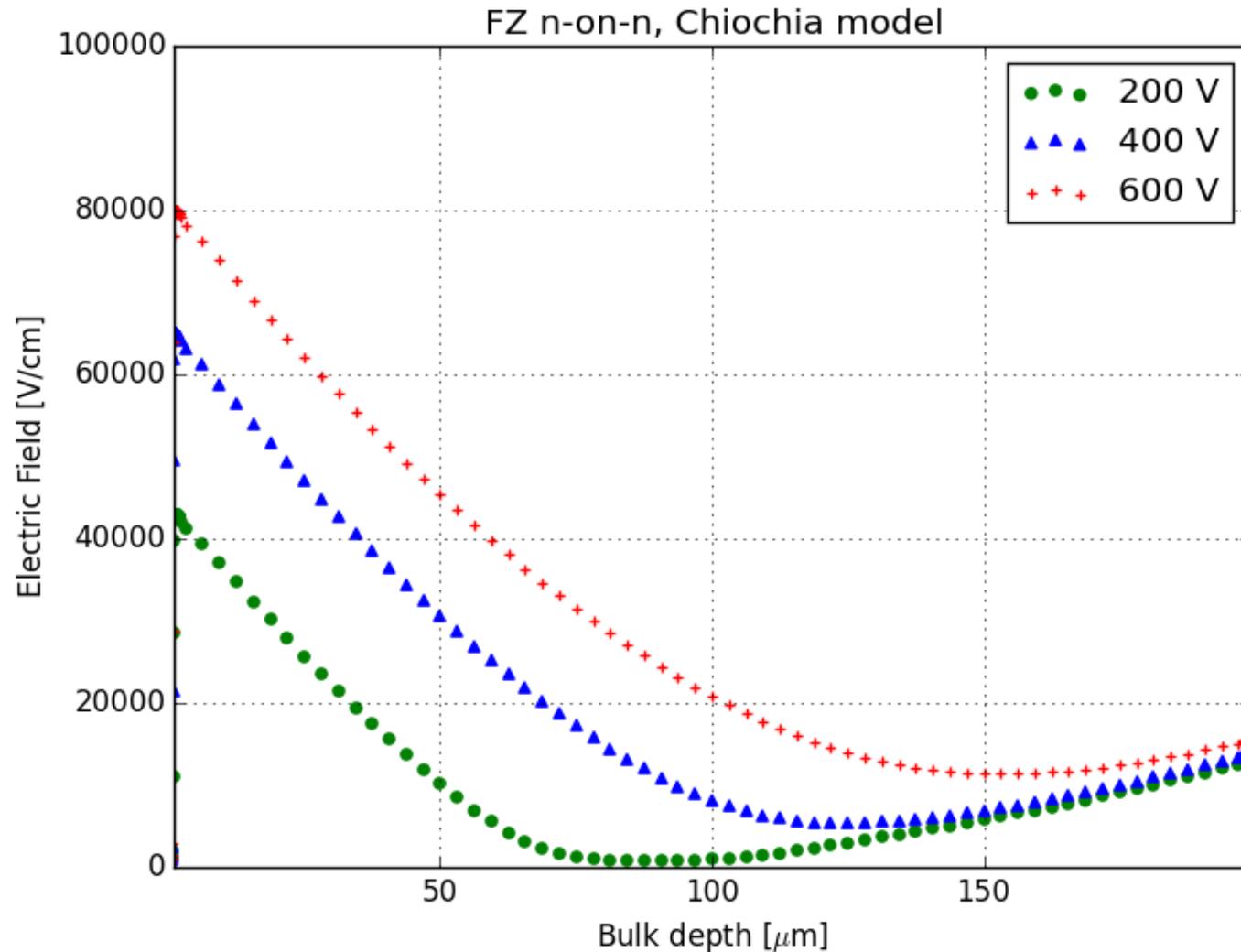
## Chiochia model for N-type

$\Phi$ (n <sub>eq</sub> /cm <sup>2</sup> ) ( $\times 10^{14}$ )	$N_A$ (cm <sup>-3</sup> ) ( $\times 10^{15}$ )	$N_D$ (cm <sup>-3</sup> ) ( $\times 10^{15}$ )	$\sigma_e^{A/D}$ (cm <sup>2</sup> ) ( $\times 10^{-15}$ )	$\sigma_h^A$ (cm <sup>2</sup> ) ( $\times 10^{-15}$ )	(cm <sup>2</sup> ) $\sigma_h^D$ ( $\times 10^{-15}$ )
0.5	0.19	0.25	6.60	1.65	6.60
2	0.68	1.0	6.60	1.65	6.60
5.9	1.60	4.0	6.60	1.65	1.65

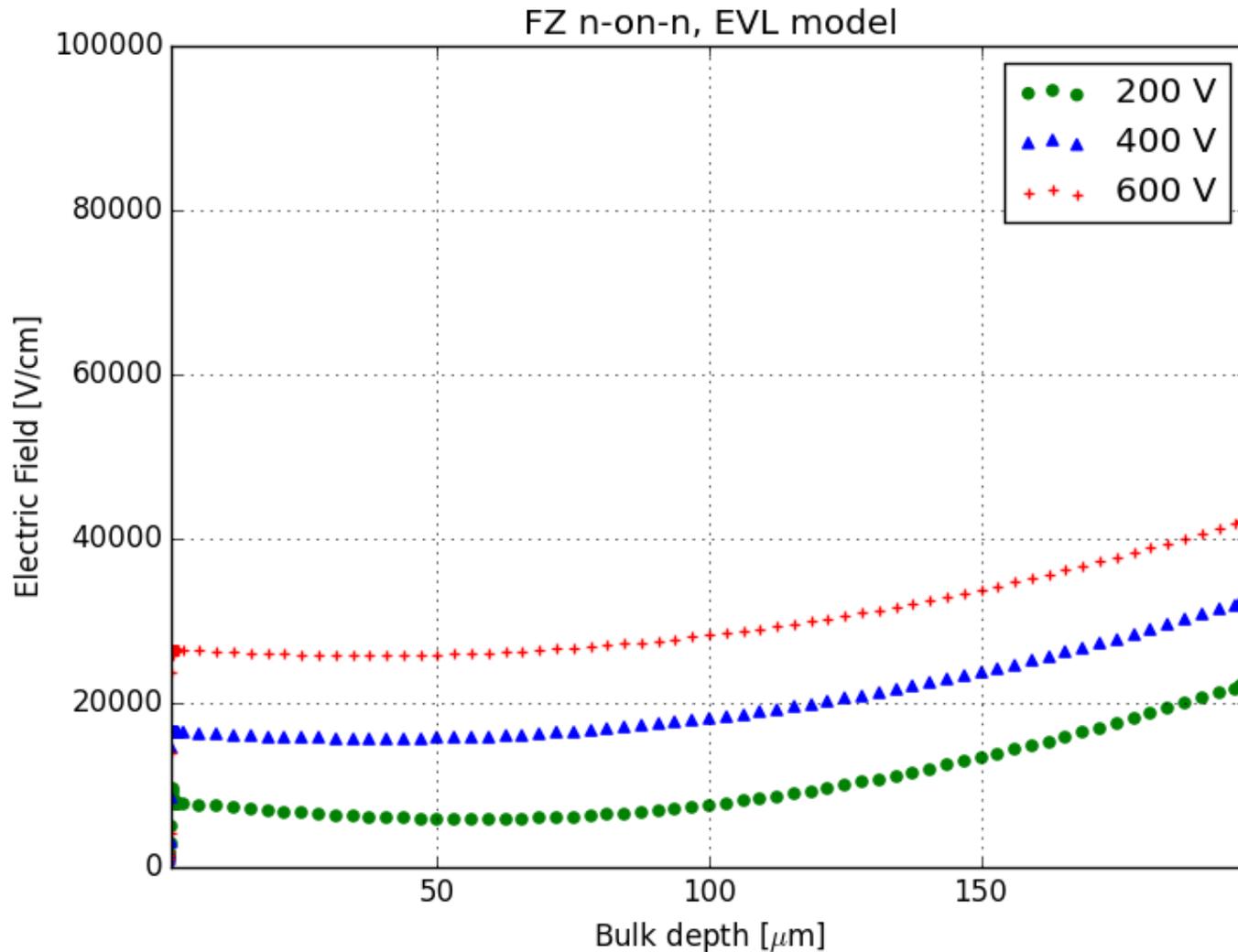


# **THIN N-ON-N SENSORS**

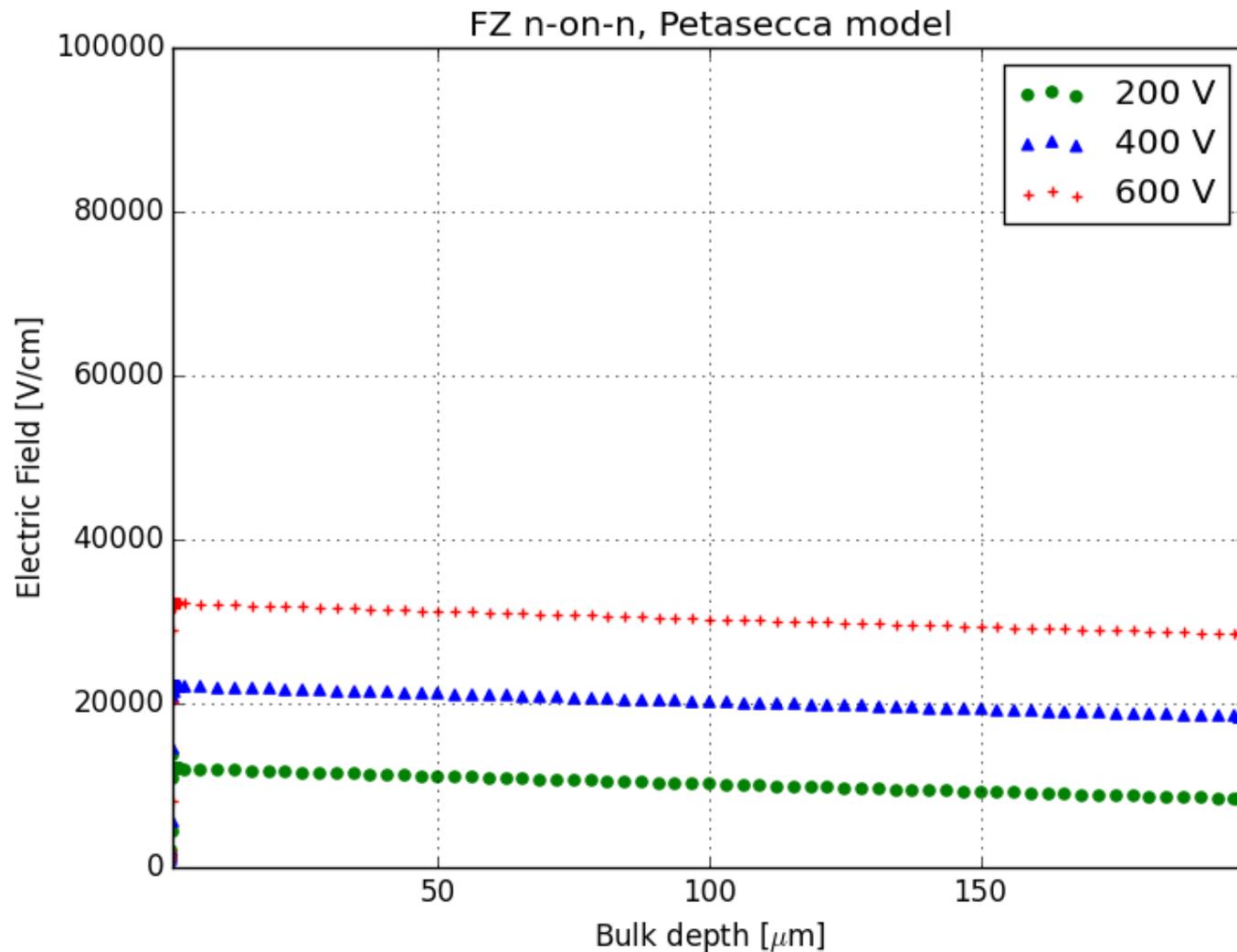
# DO\_FZ – Electric field profile



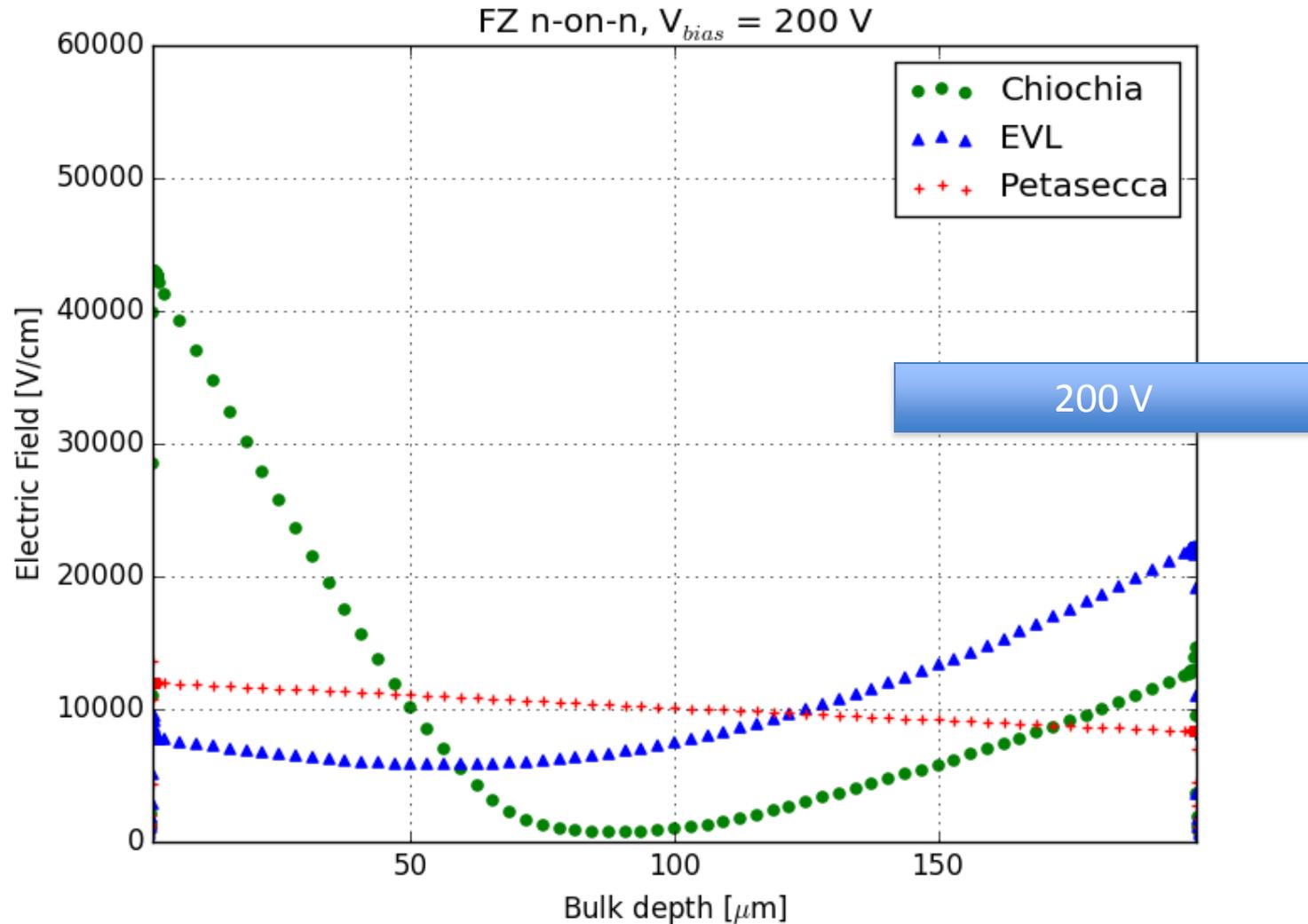
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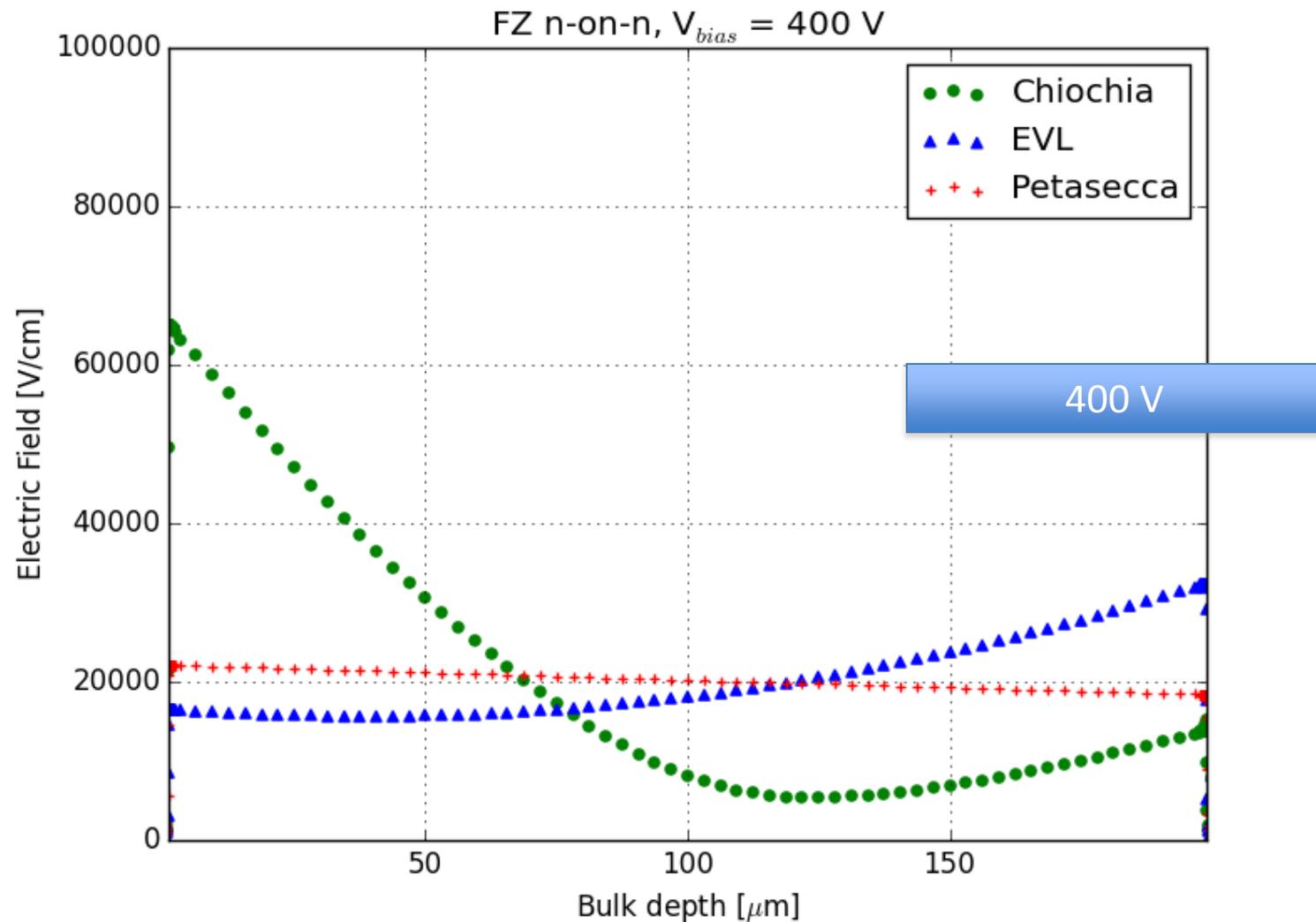
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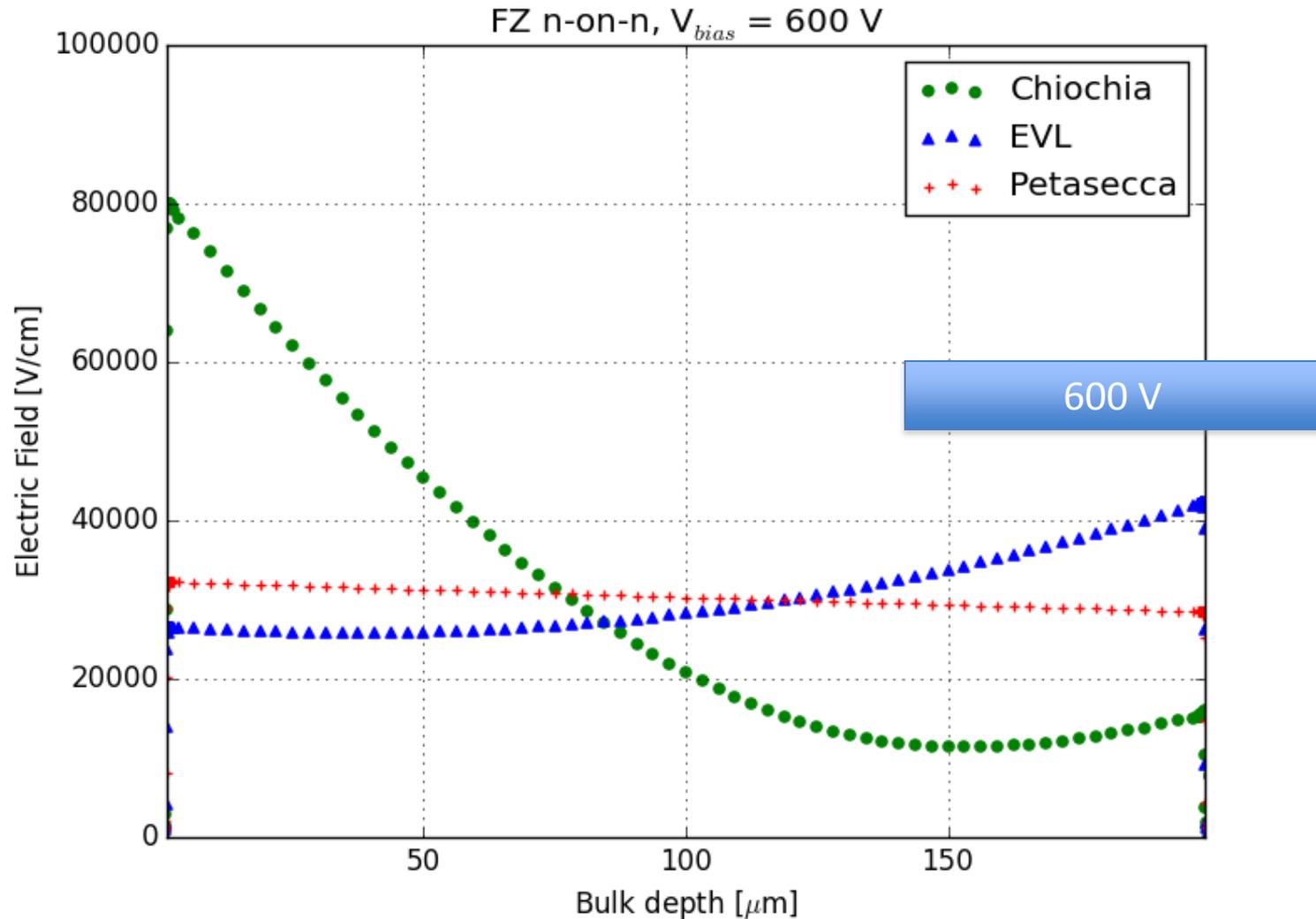
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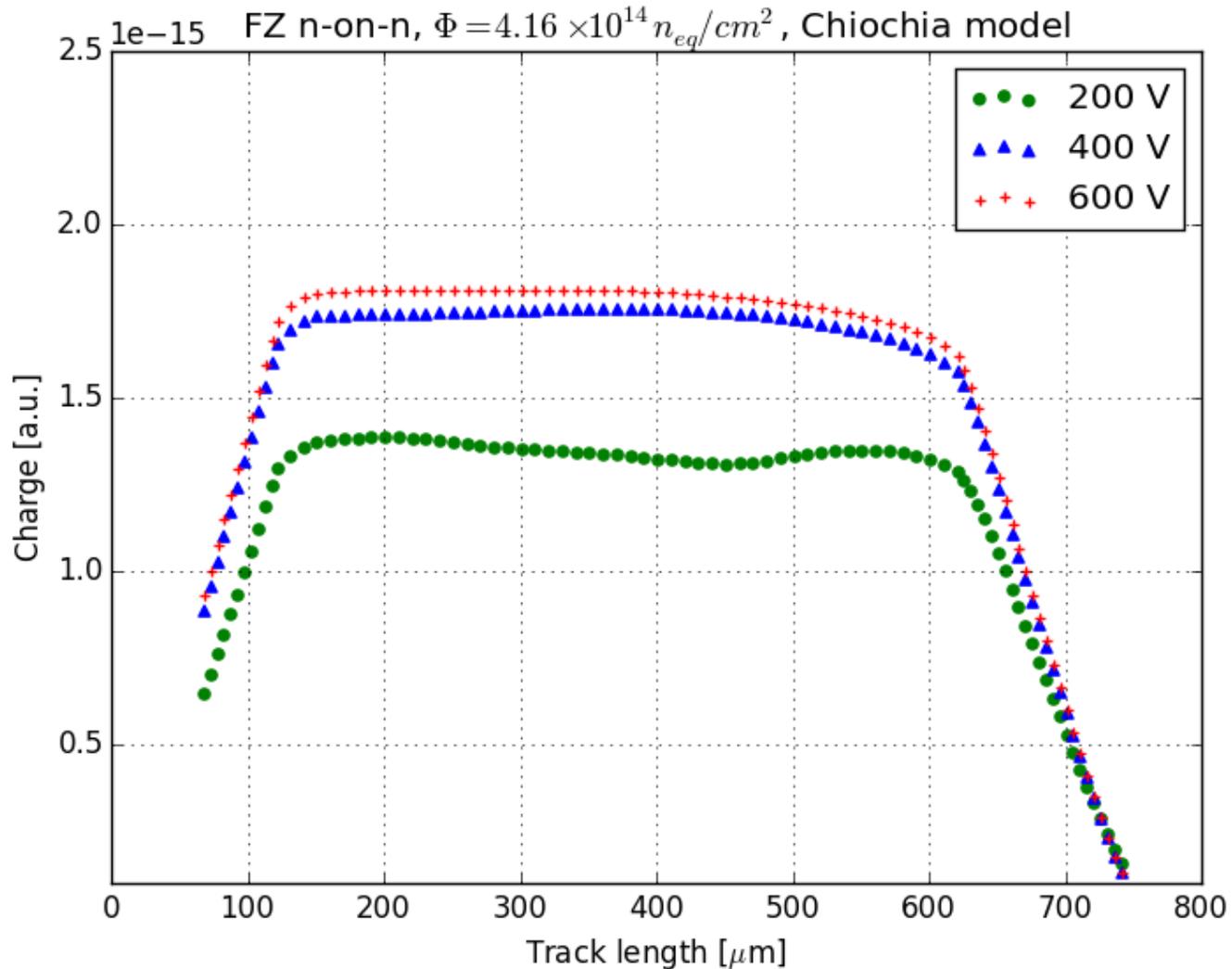
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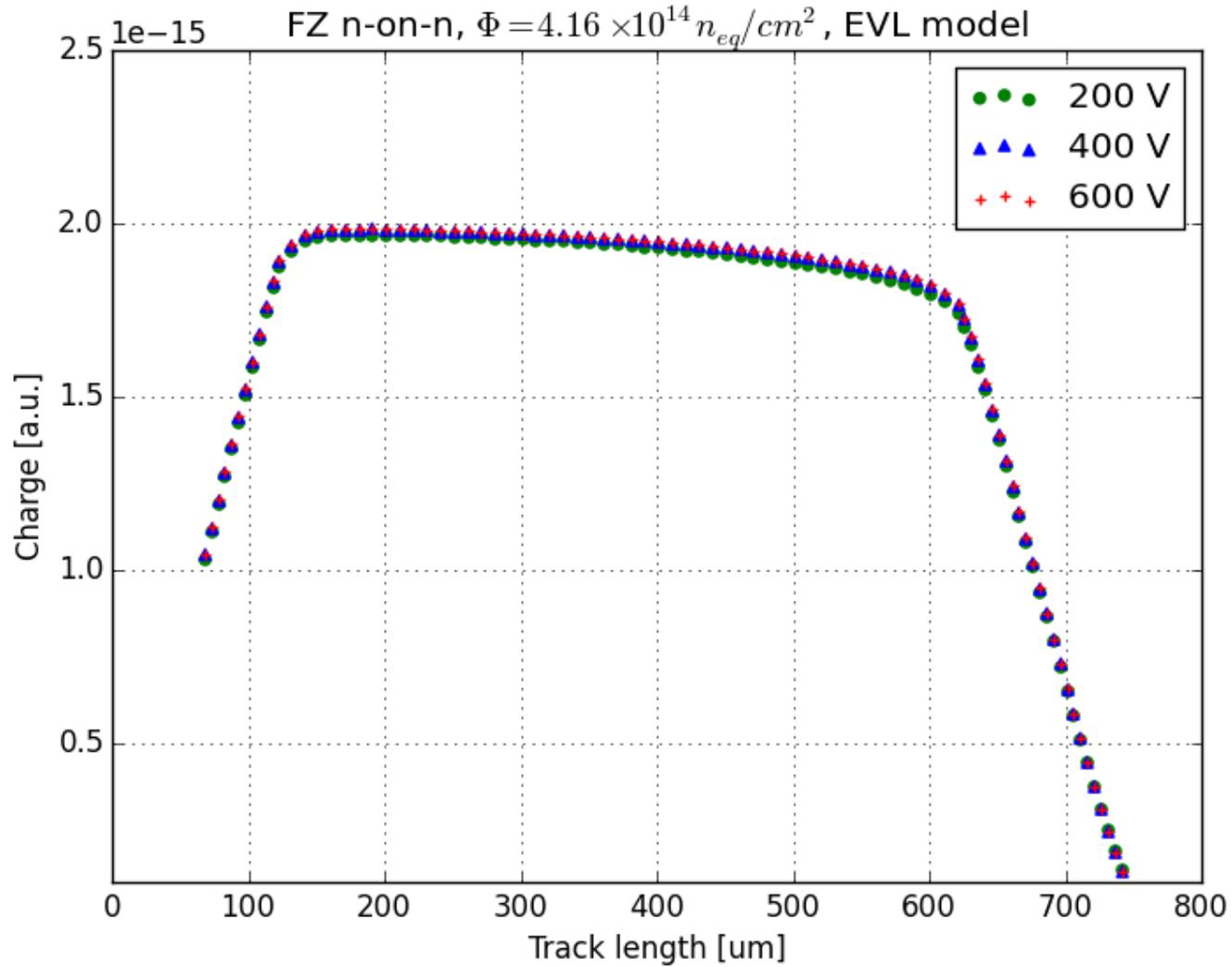
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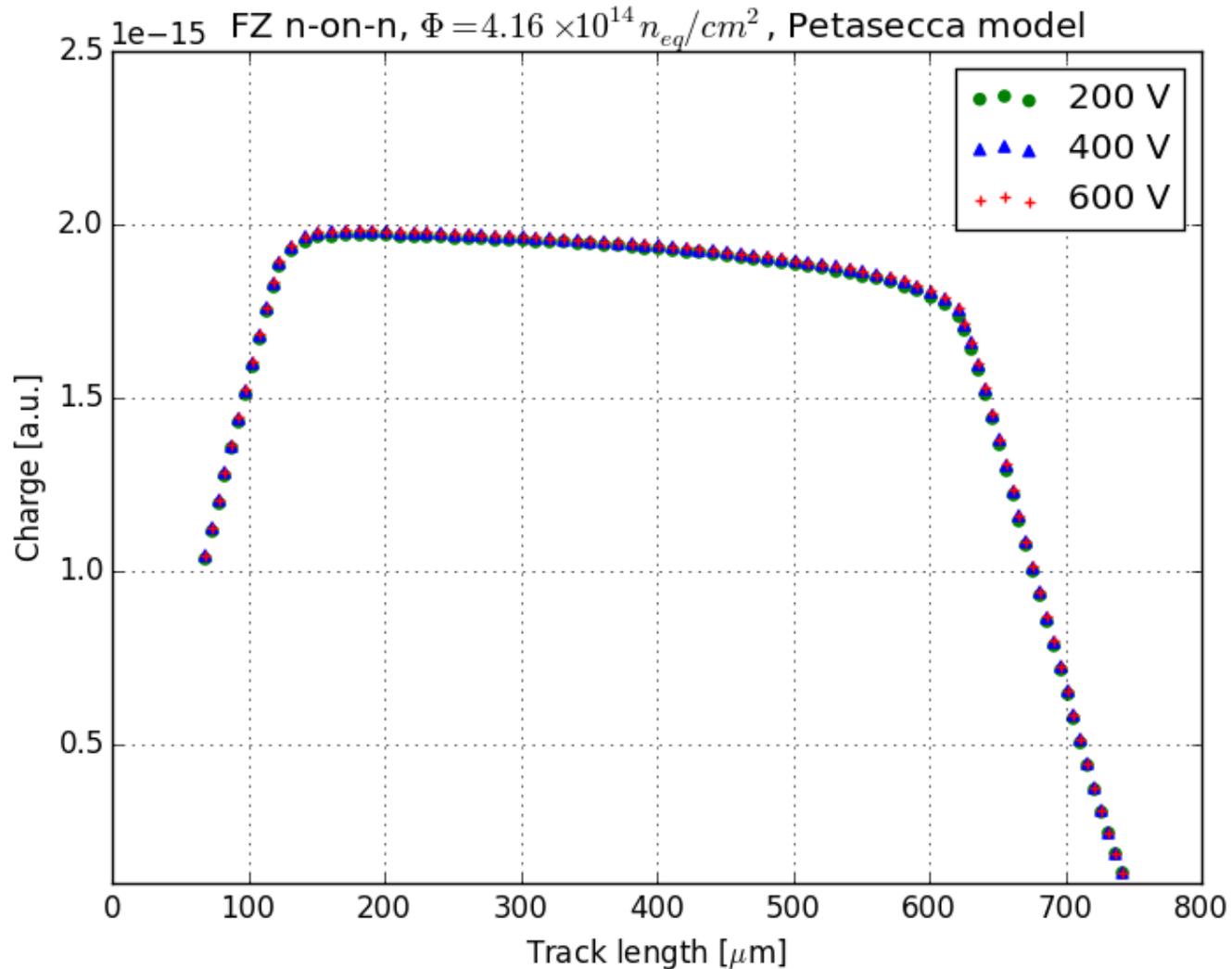
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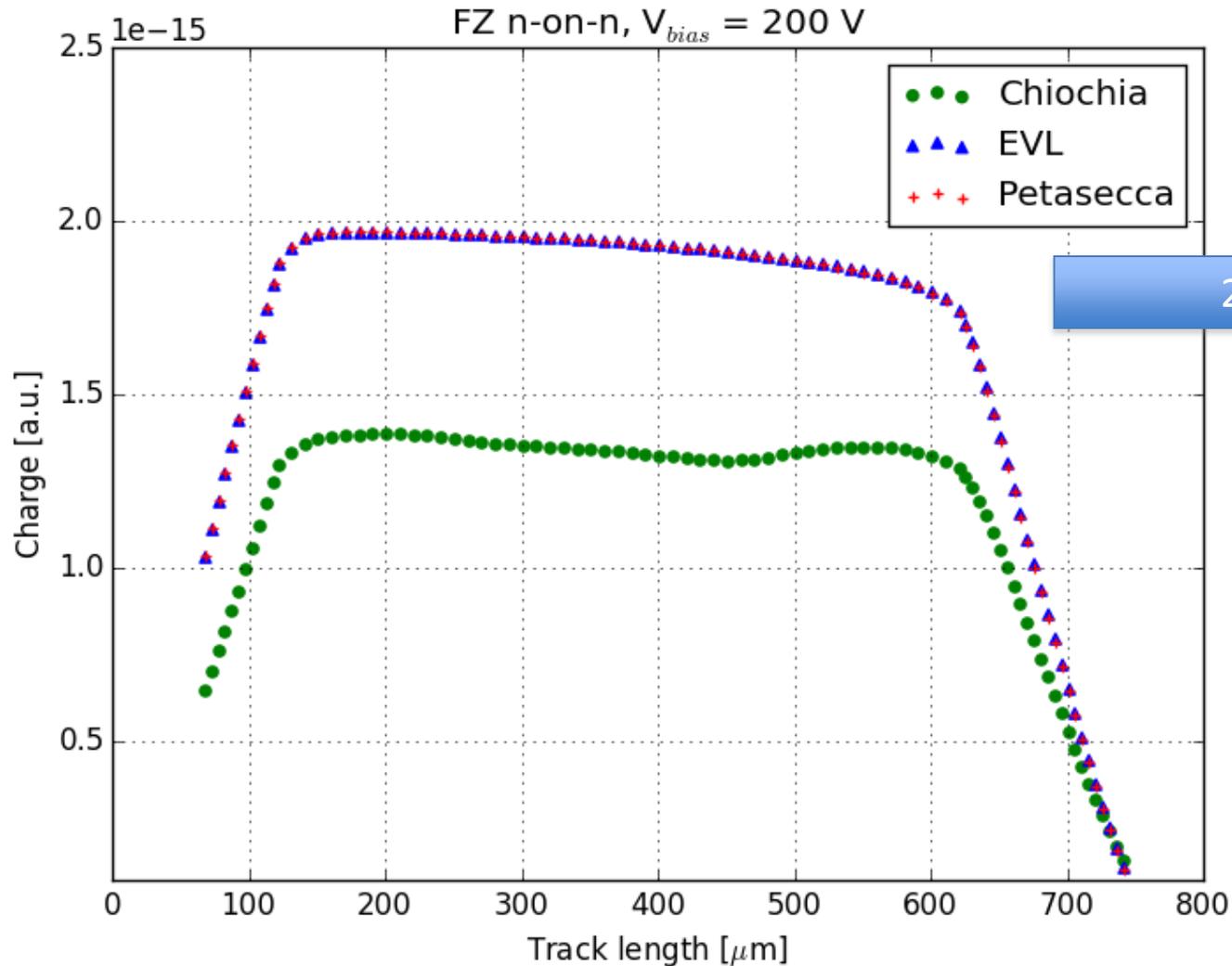
# DO\_FZ – Charge profile



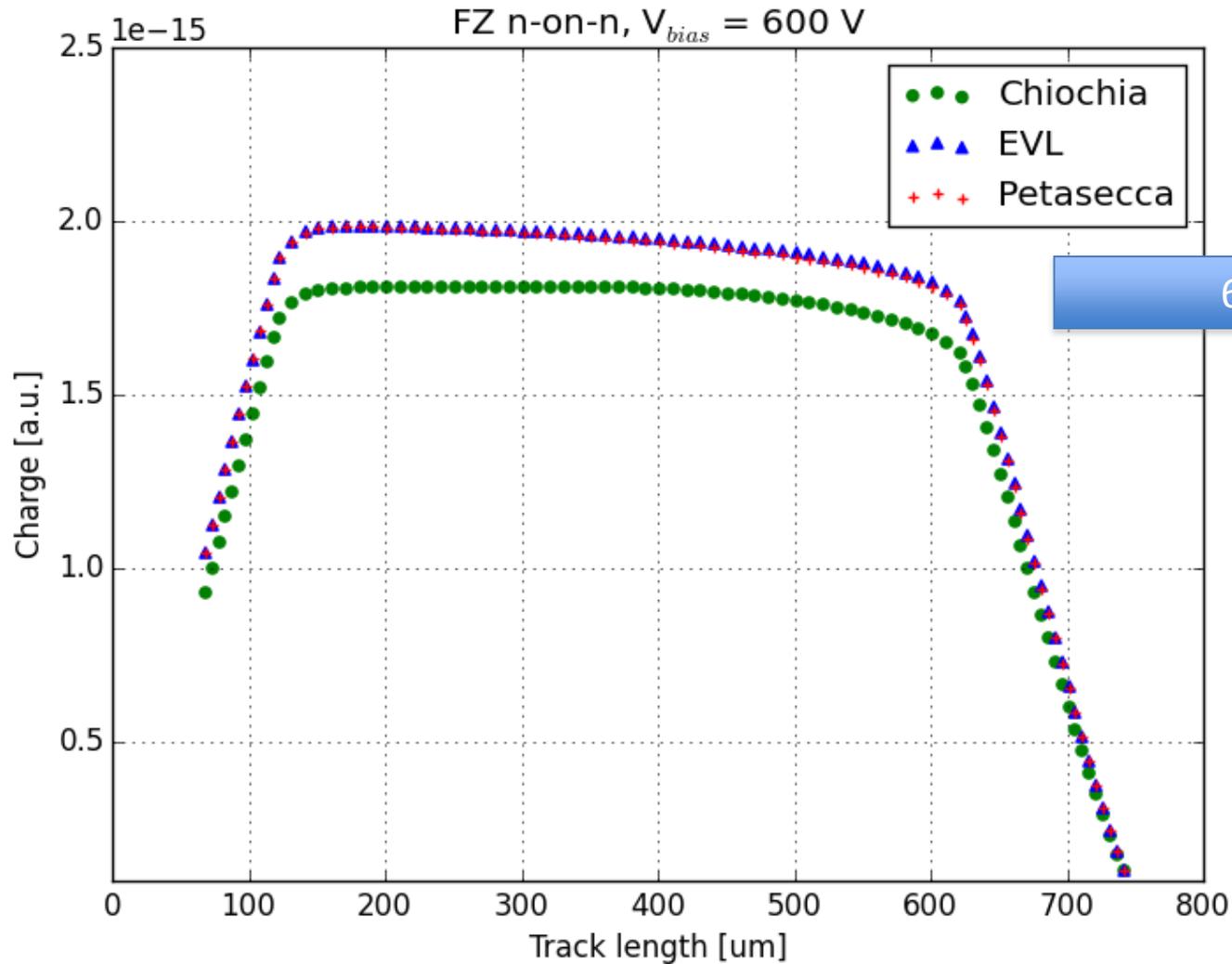
# DO\_FZ – Charge profile

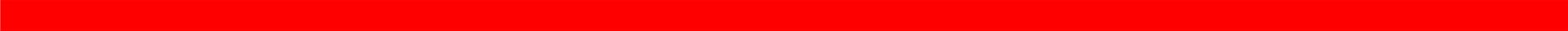


# DO\_FZ – Charge profile comparison



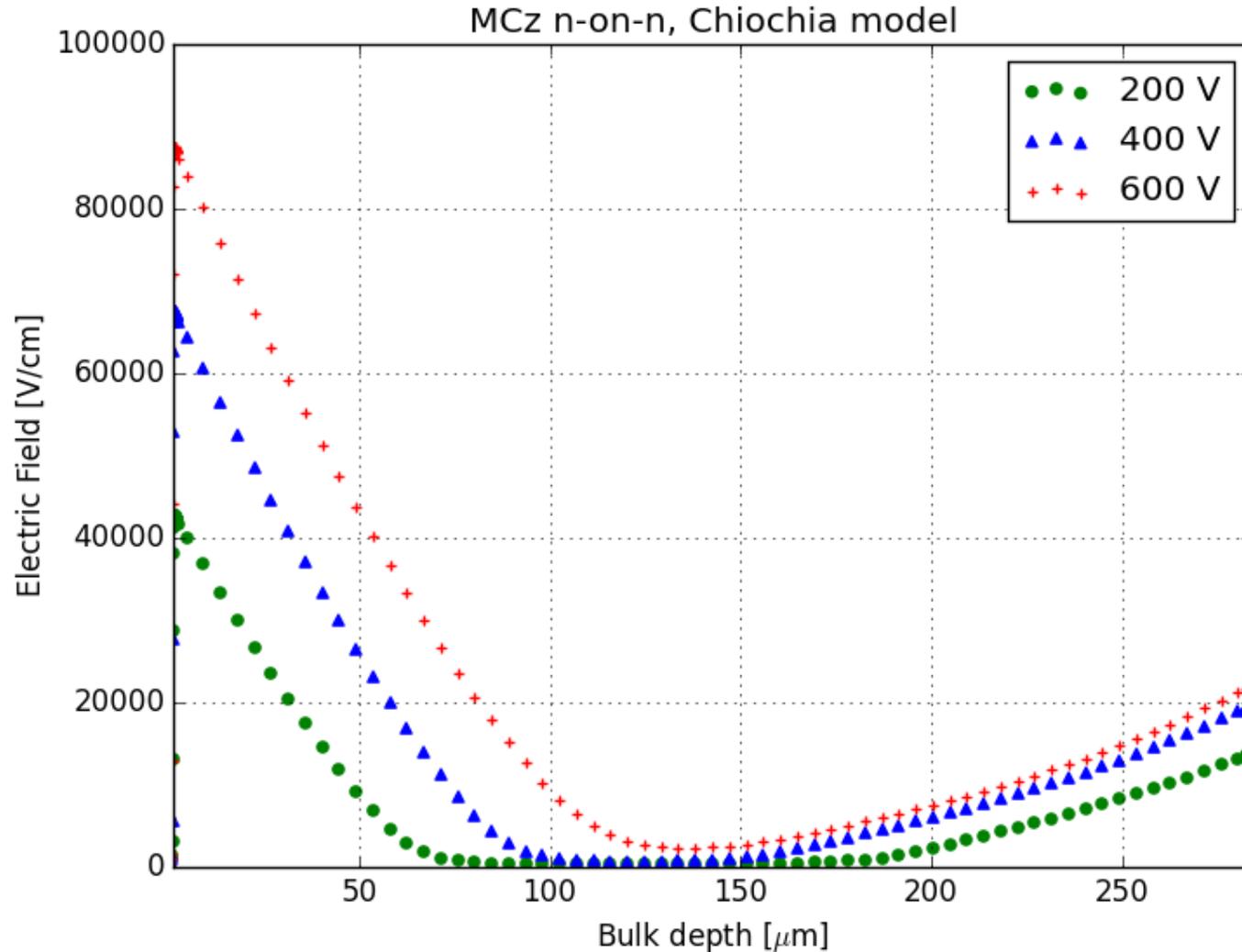
# DO\_FZ – Charge profile comparison



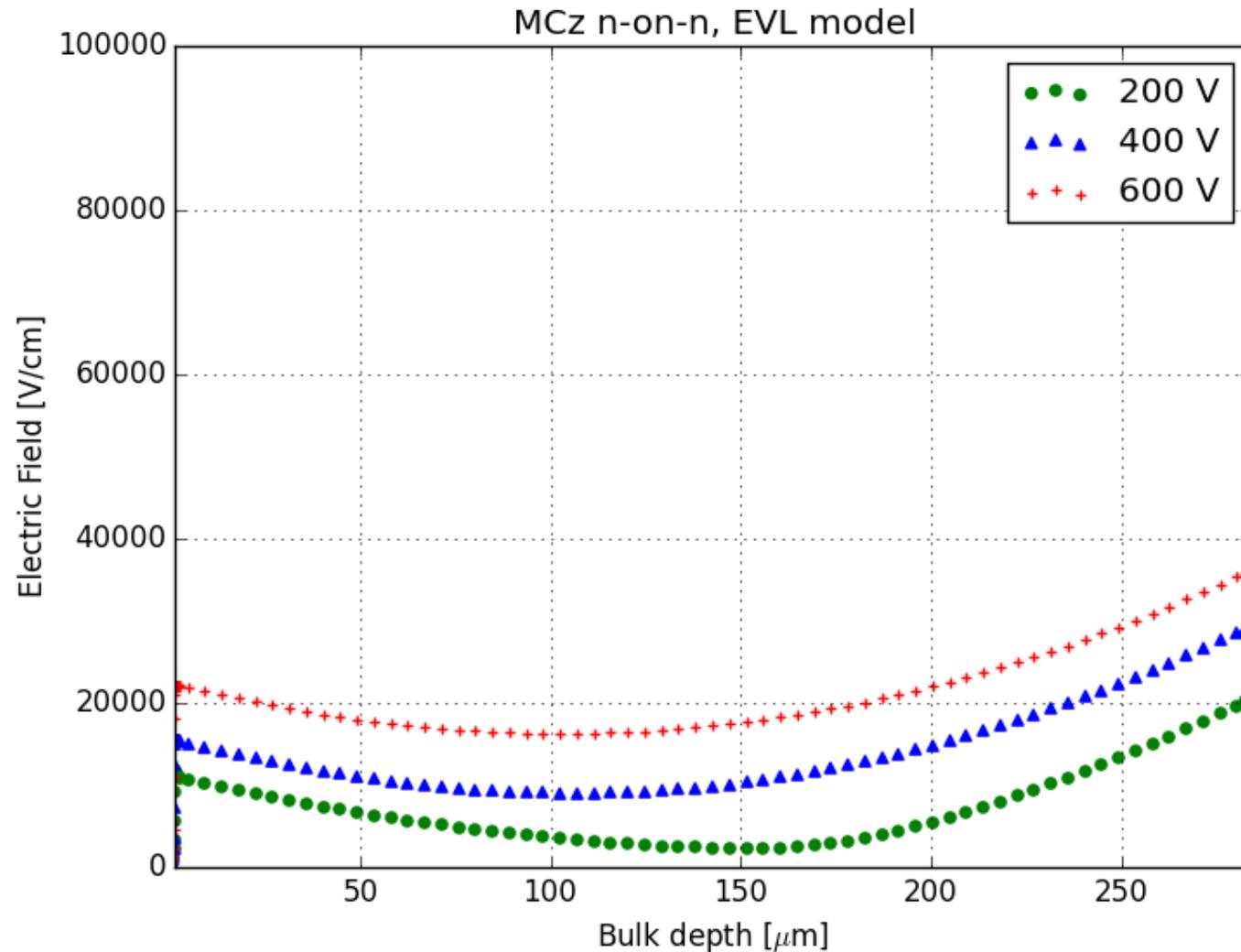


# **THICK N-ON-N SENSOR**

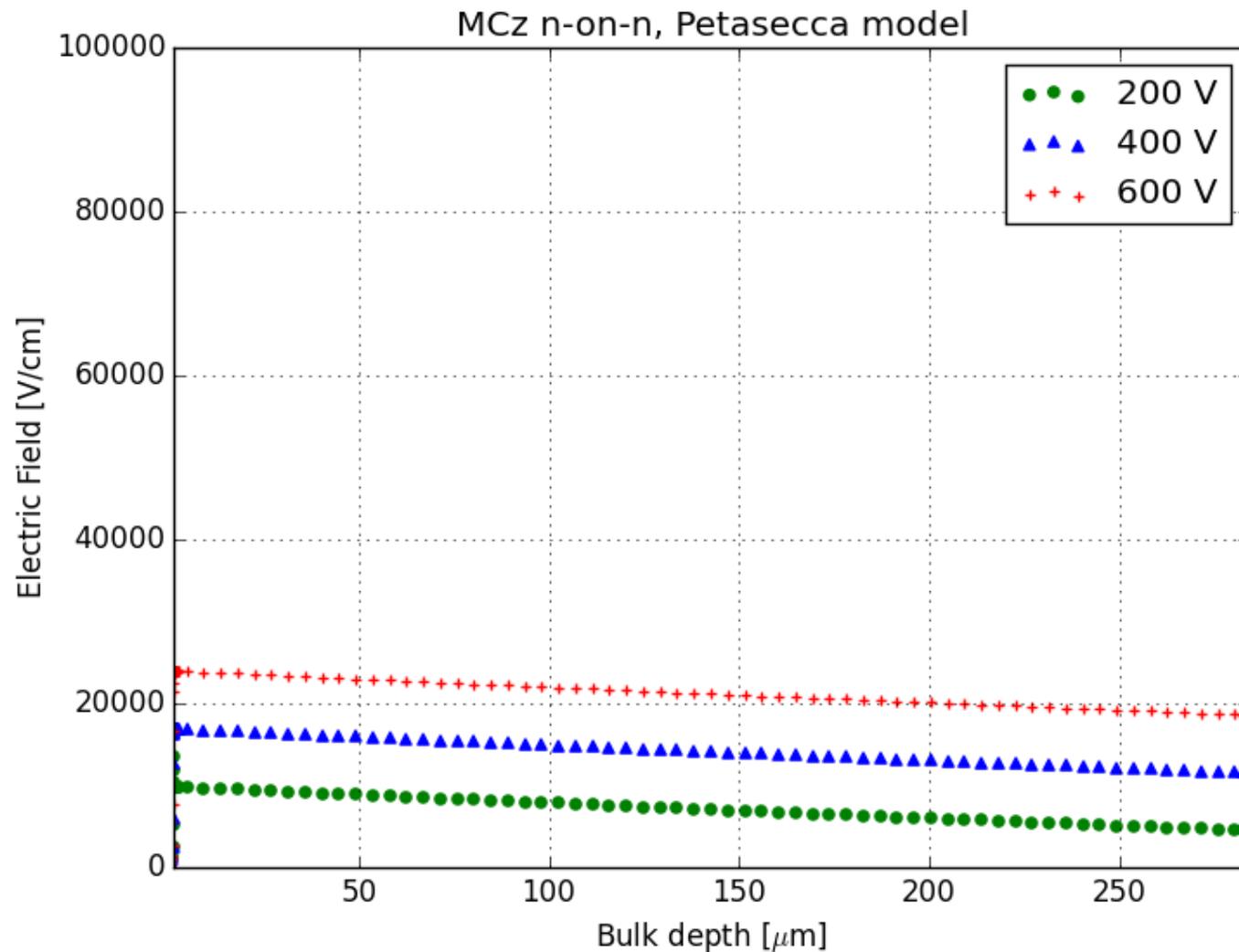
# DO\_MCz – Electric field profile



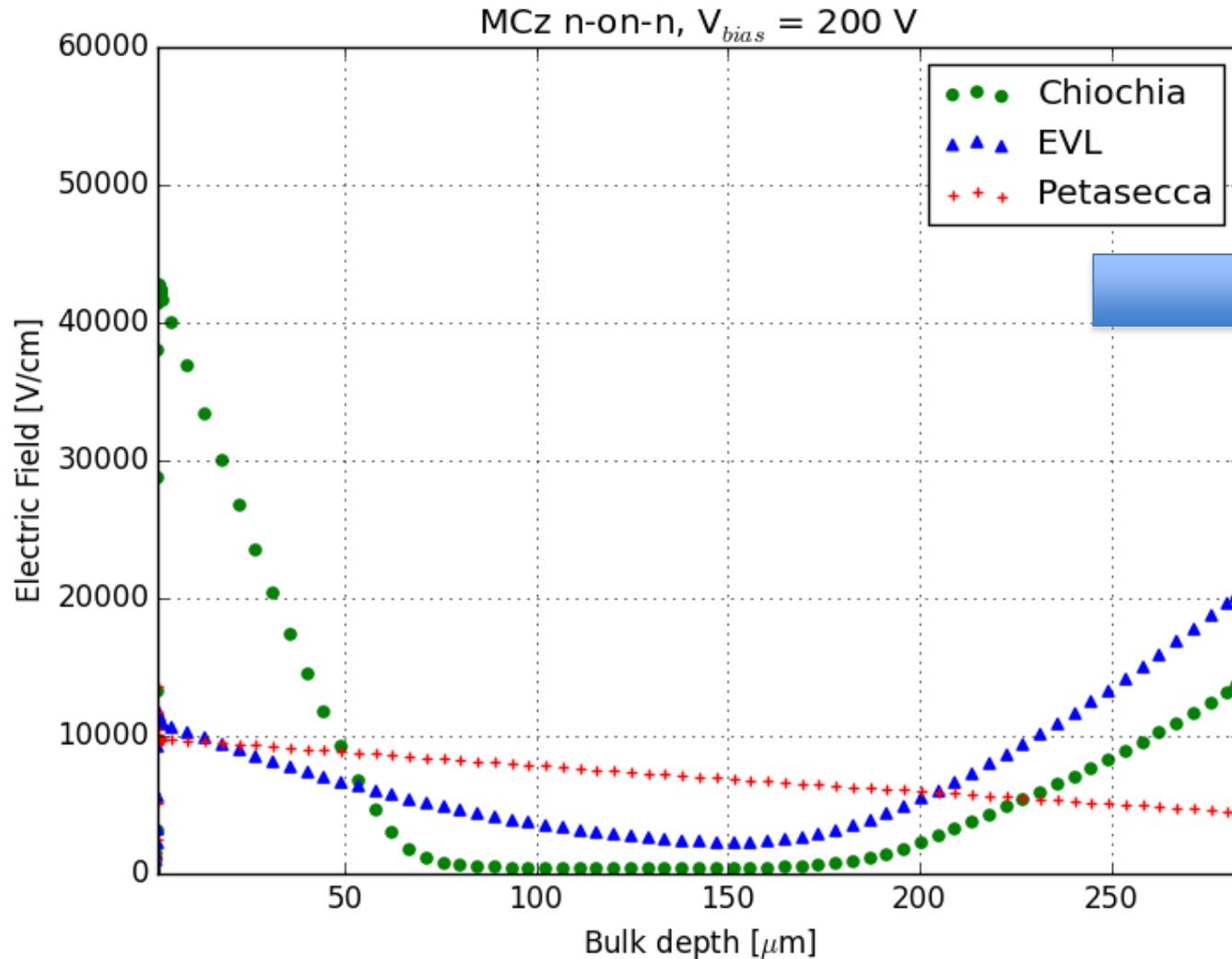
# DO\_MCz – Electric field profile



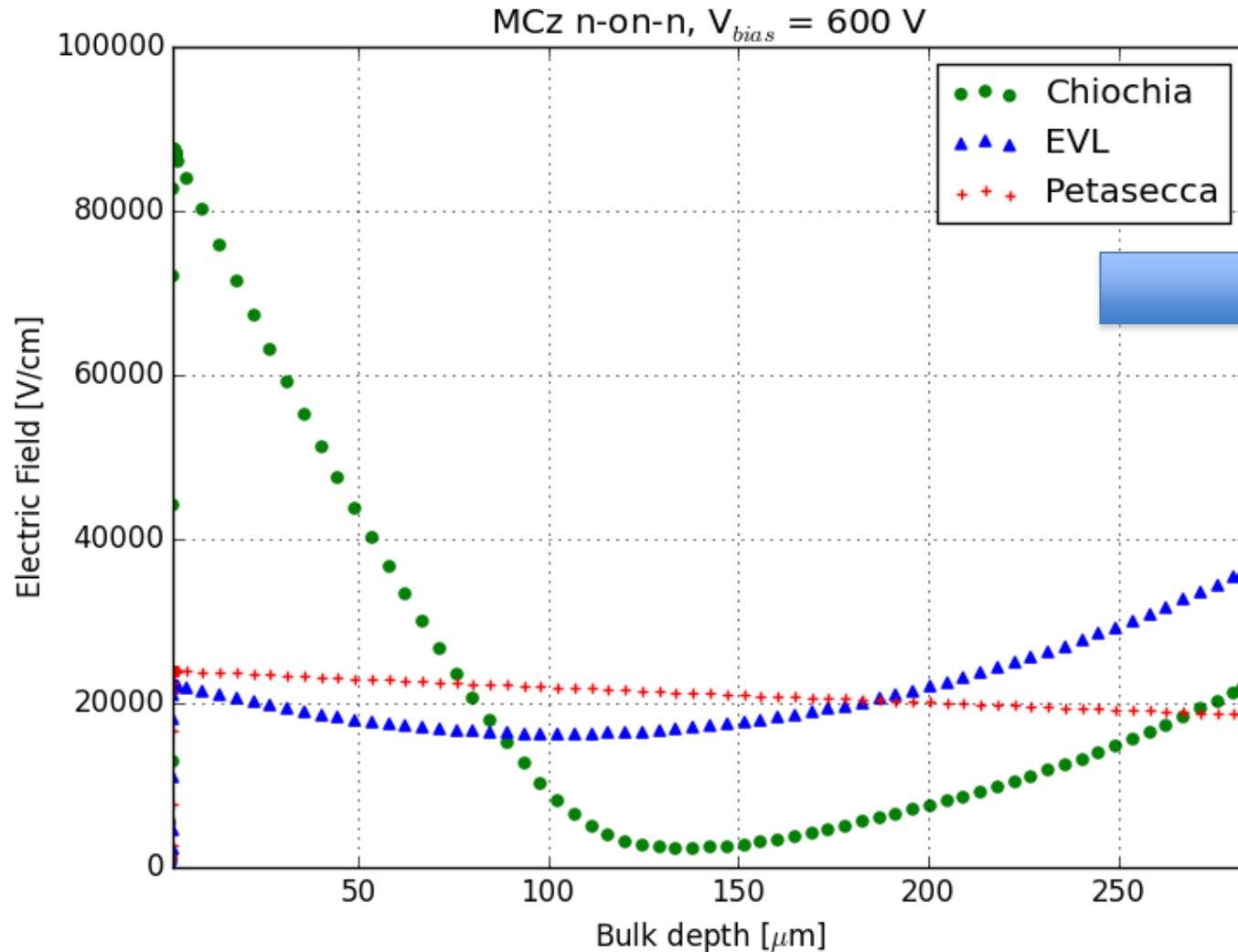
# DO\_MCz – Electric field profile



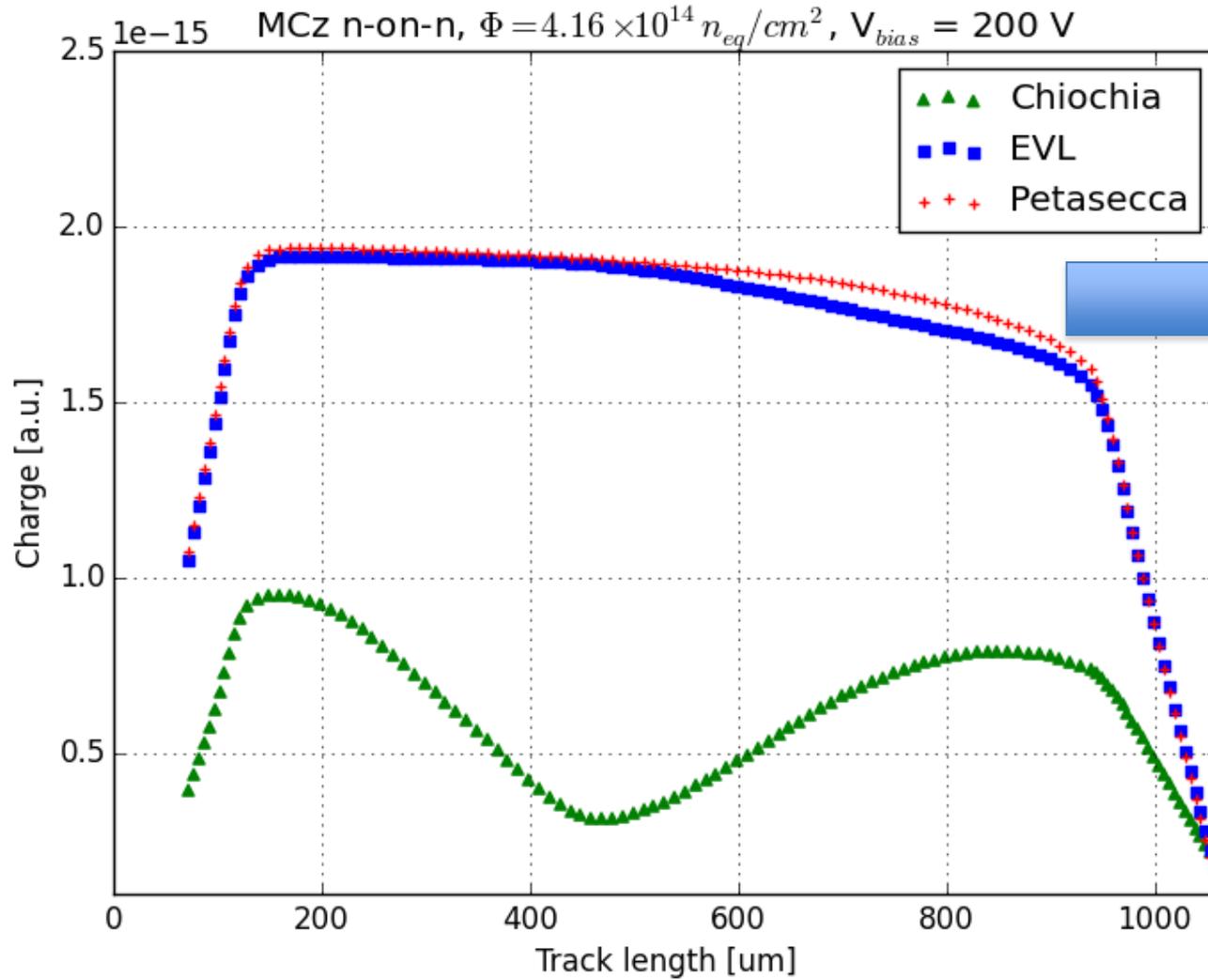
# DO\_MCz – Electric field profile comparison



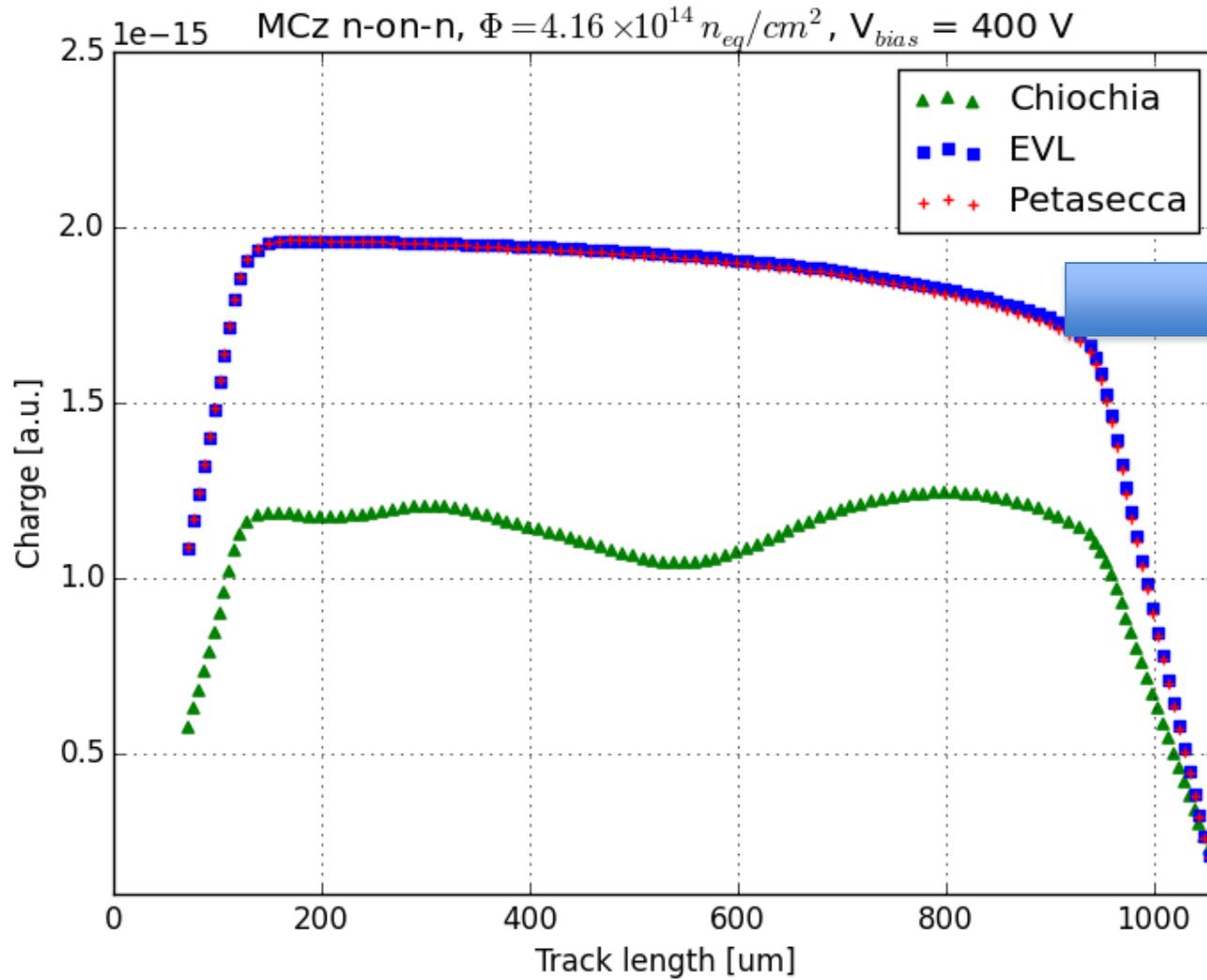
# DO\_MCz – Electric field profile comparison



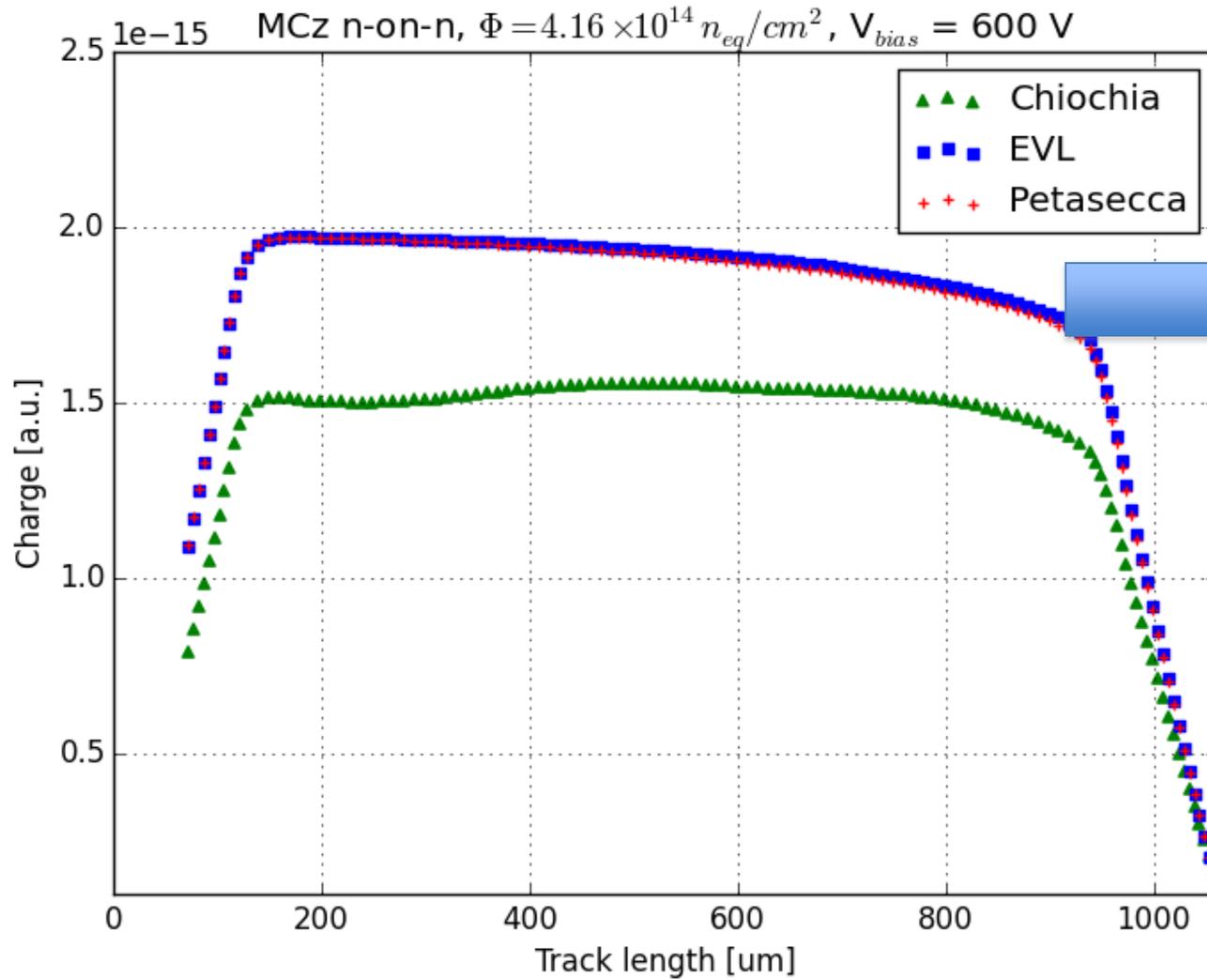
# DO\_MCz – Charge profile



# DO\_MCz – Charge profile



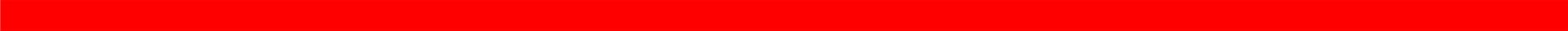
# DO\_MCz – Charge profile



# Discussion of n-on-n results

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- At very low fluence only the Chiochia model predicts a quite “structured” charge profile
  - But only for small bias voltages
- The test has to be repeated for larger fluences



# **CONCLUSIONS & OUTLOOK**

# Conclusions & outlook

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- Combining testbeam data & TCAD simulations for irradiated sensors could give access to important sensor properties like:
  - The electric field profile
  - The trapping constant
- Detailed simulations for a variety of samples and different radiation damage models have been produced
- Looking forward some testbeam data to compare simulations to